

Optimizing Phase Contrast in TEM by the use of an electrostatic Boersch Phase Plate

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Fabian Pérez-Willard

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Endre Majorovits

MPI Med. Research / University Oxford

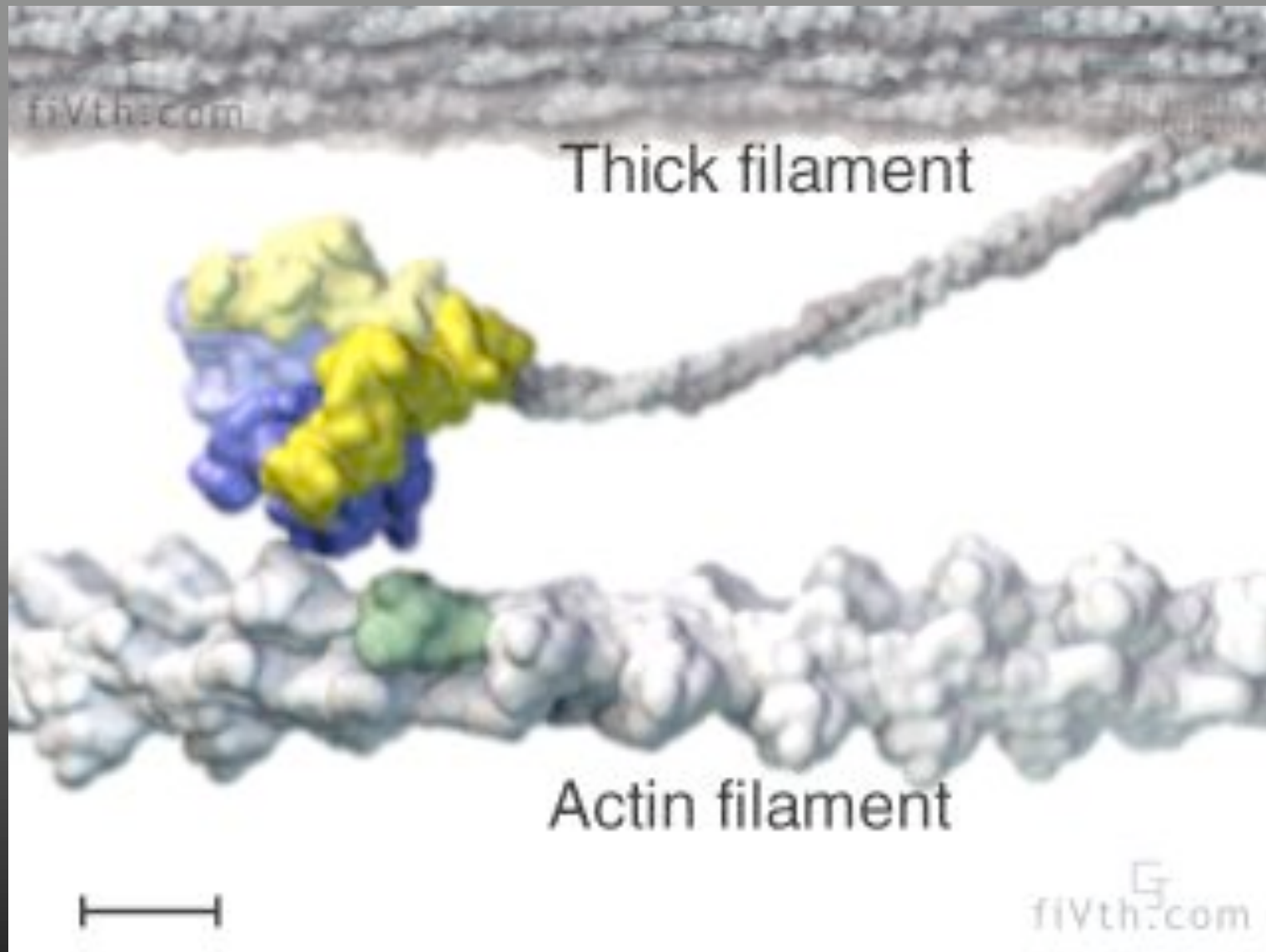
Radostin Danev

NIPS, Okazaki University

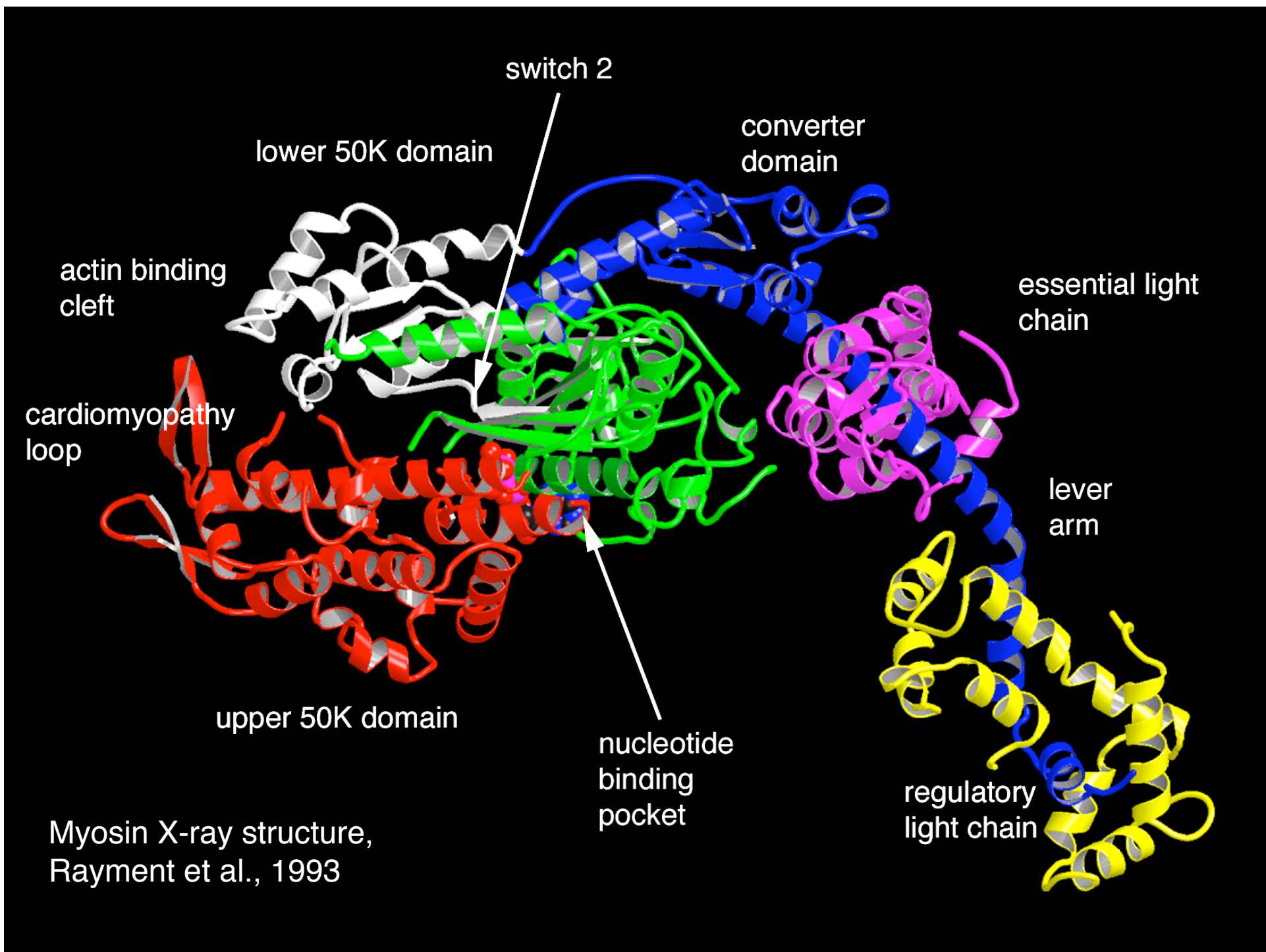
Kuniaki Nagayama

Werner Kühlbrandt

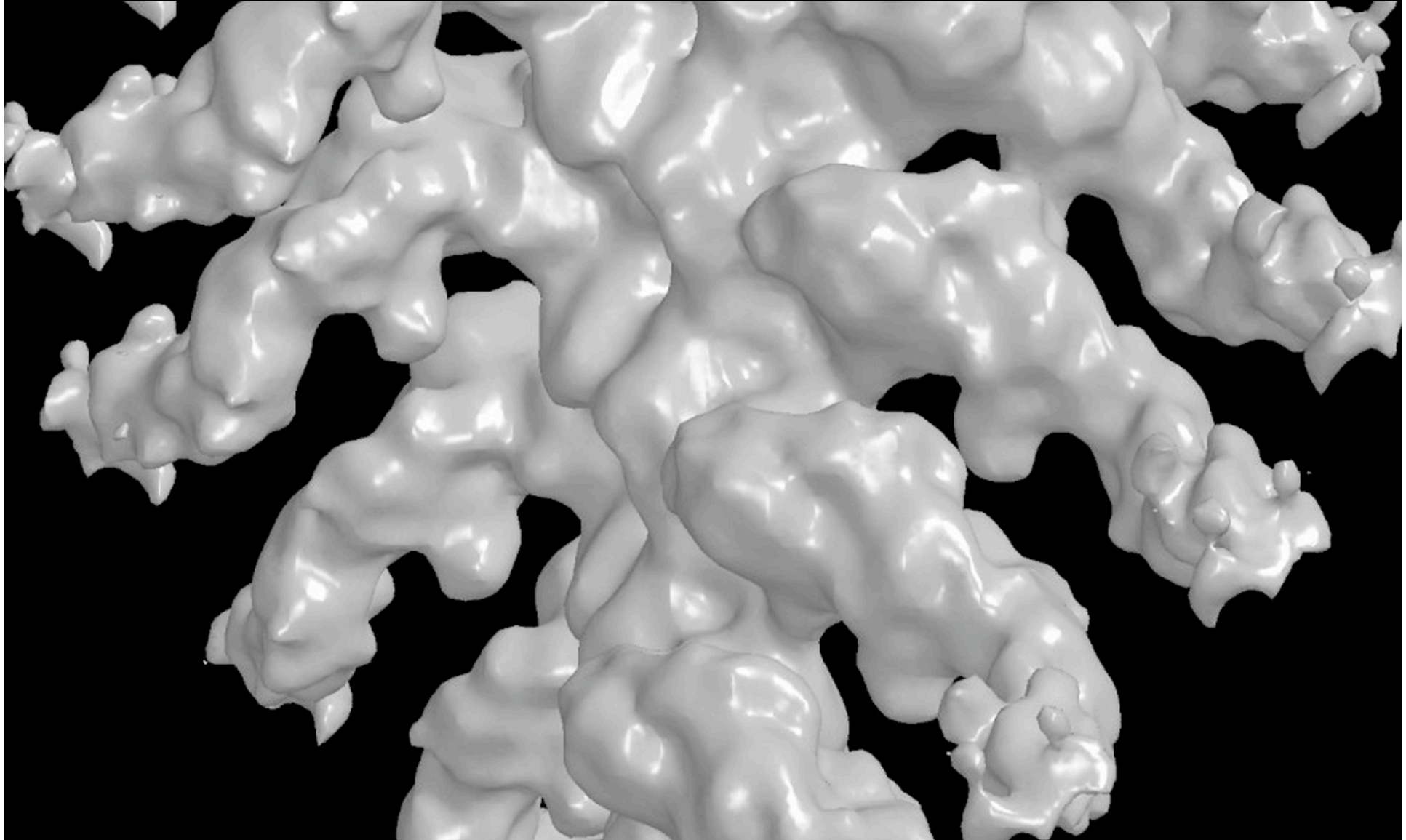
MPI Biophysics, Frankfurt/Main

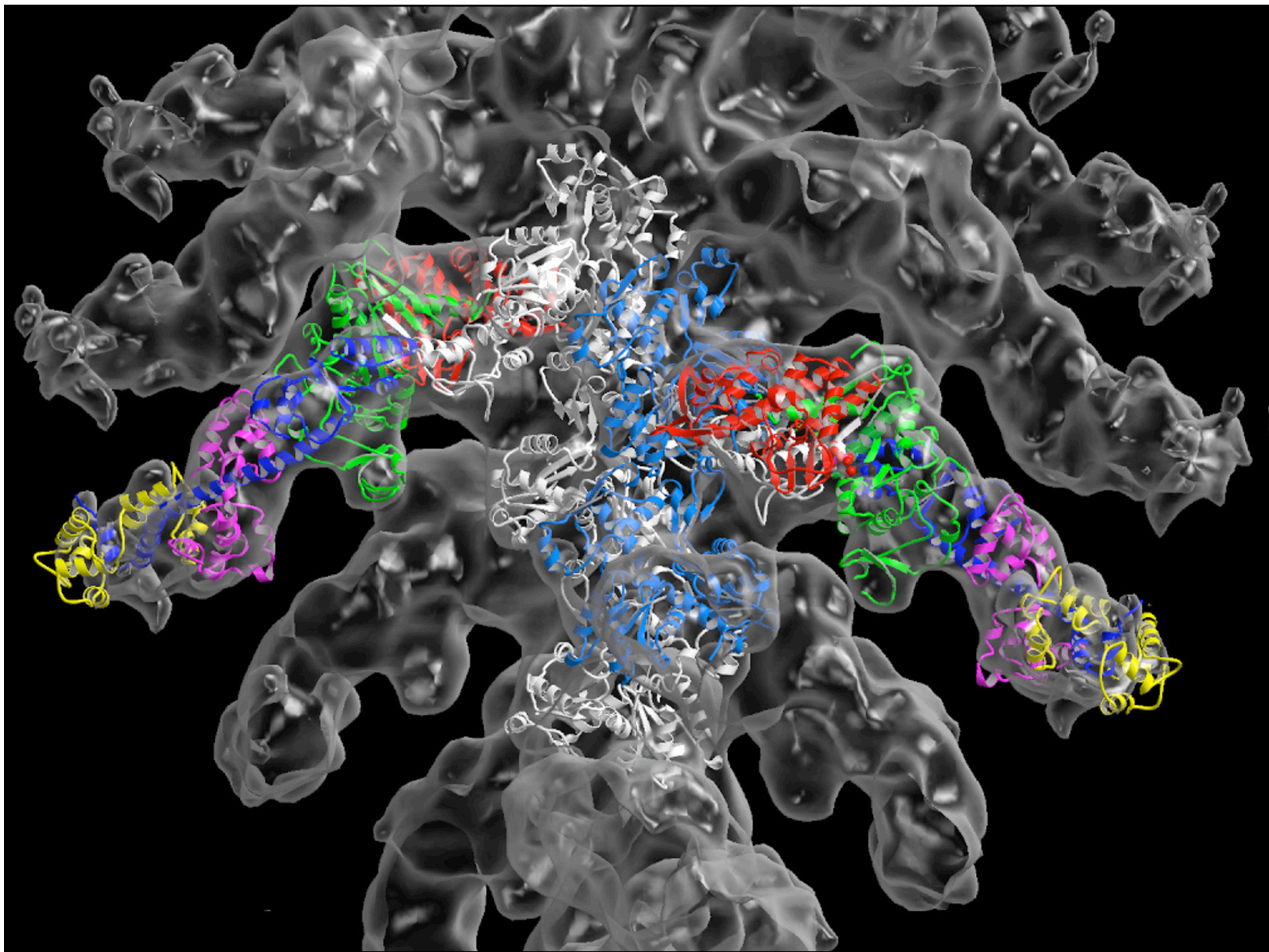


“How muscle works ...”, from Ron Vales’s web page

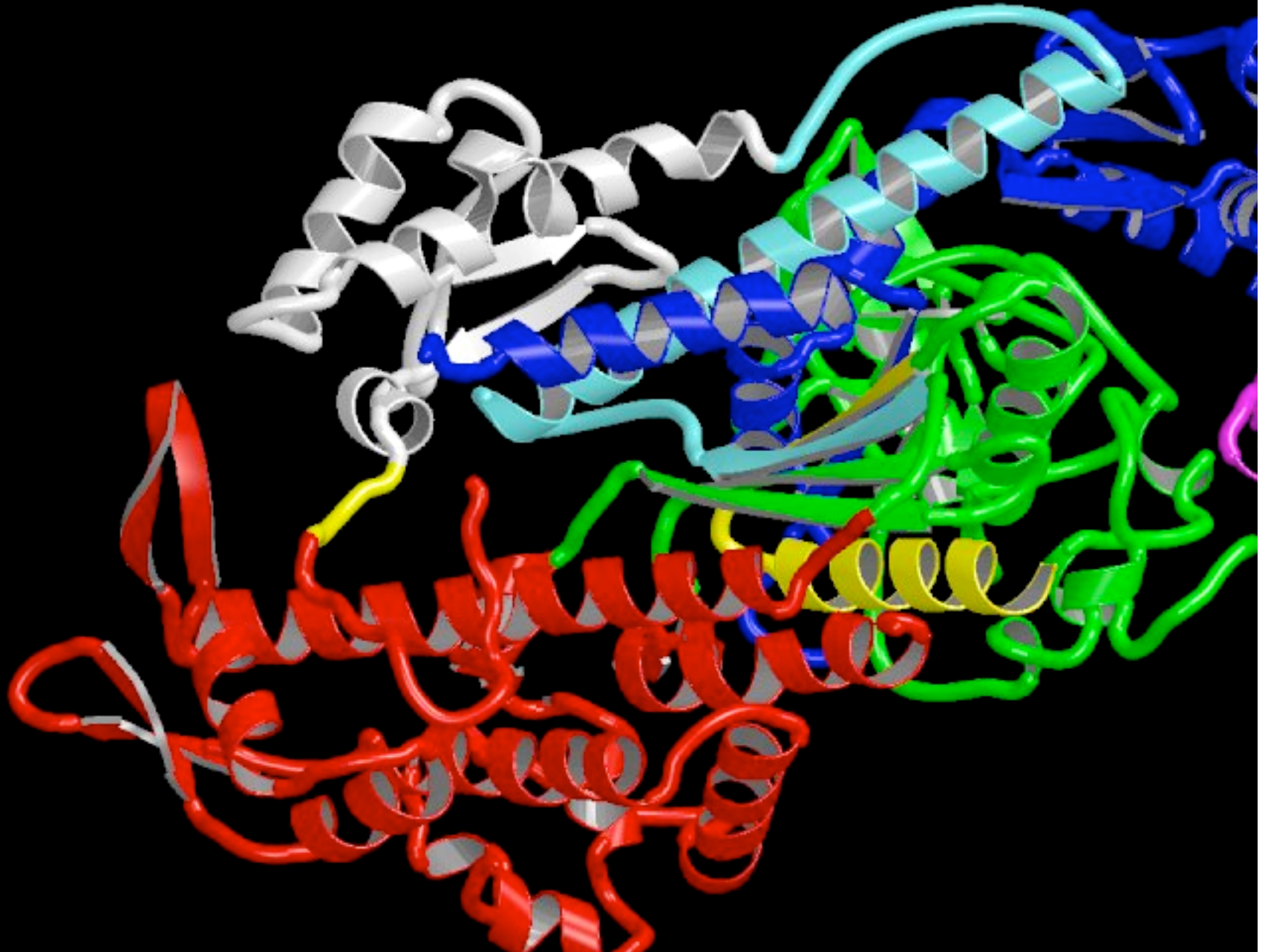


**Reconstruction of the rigor actin-myosin complex
(chicken skeletal myosin II papain S1, Holmes et al., 2003)
Resolution 13-15Å (Fourier shell coefficients)**

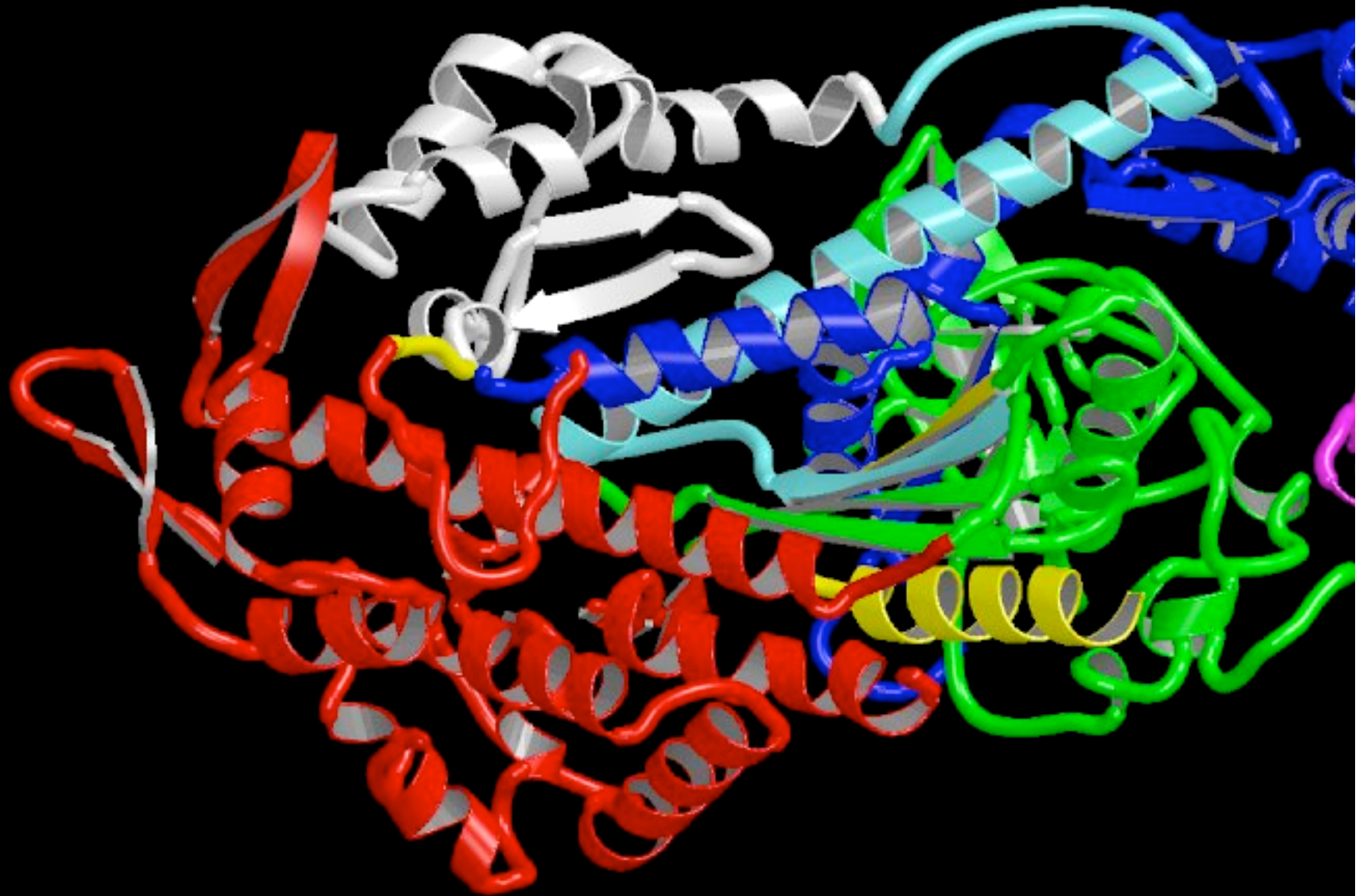


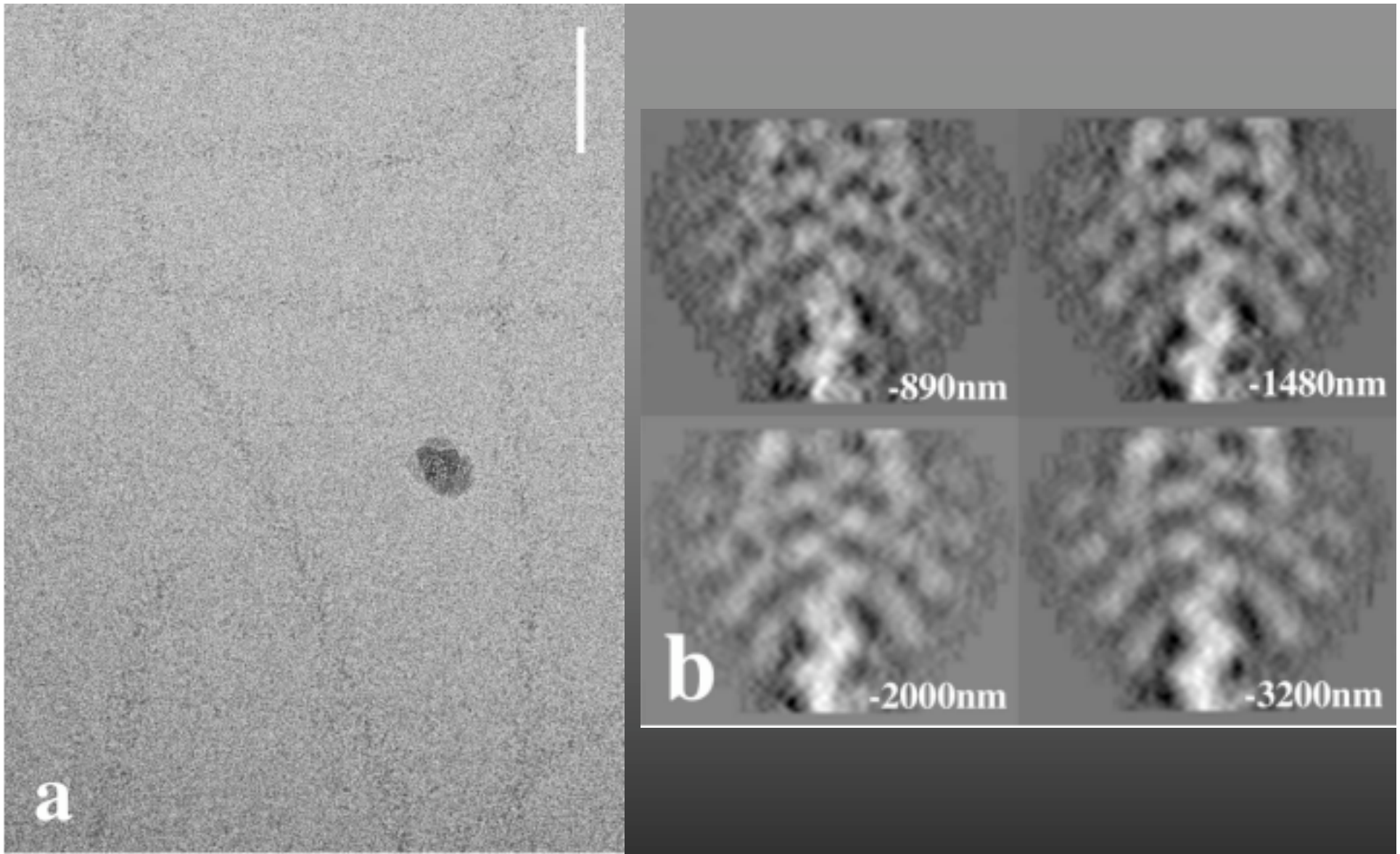


chicken skeletal



upper/lower 50K free





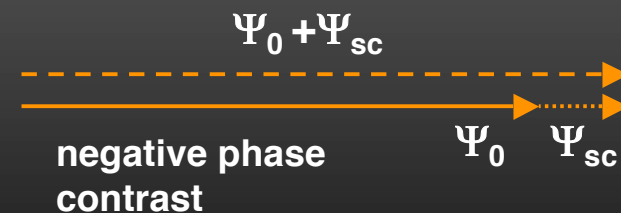
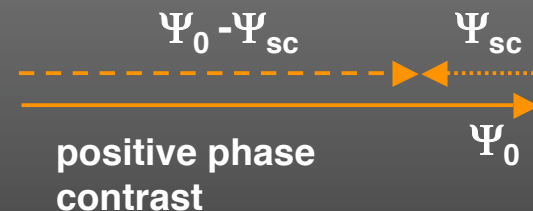
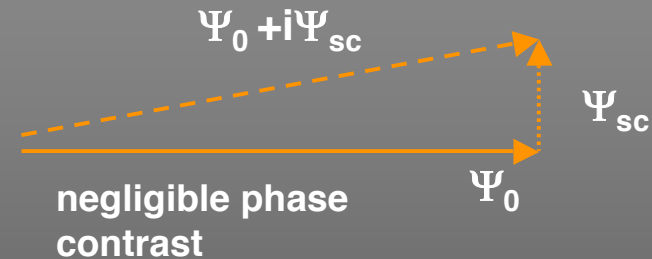
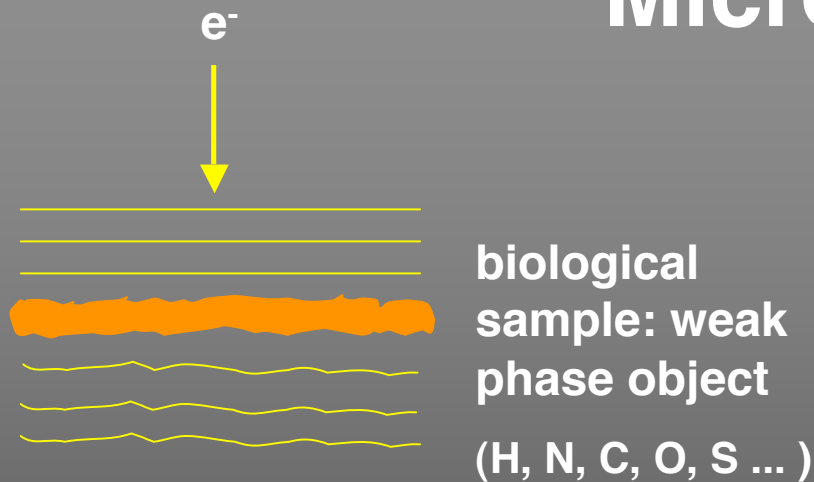
a - a typical sample of decorated actin at an underfocus of $1.48 \mu\text{m}$. (scale bar 77 nm)

b – averages of 104 identical object areas selected from the four exposures in one defocus series. Half a 38.5 nm repeat is shown for each underfocus exposure

Outline

- Phase contrast in transmission electron microscopy
- Why an electrostatic phase plate?
- The design of a Boersch-type electrostatic phase plate
- First experimental results
- The future

Phase Contrast in Electron Microscopy

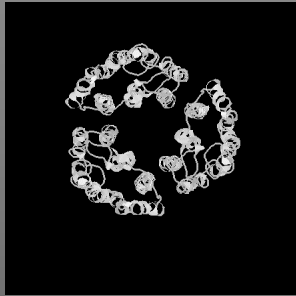


weak phase object

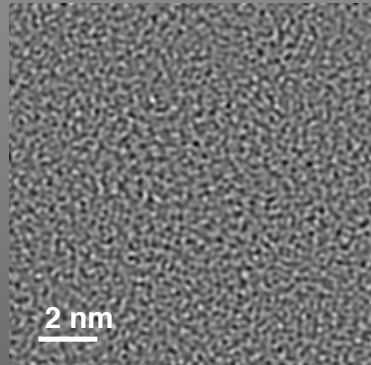
- $\pi/2$ -phase shift due to elastic scattering + small scattering amplitude (1st order Born approximation)
- negligible phase contrast
- low object signal

Simulation of bacterio rhodopsin (bR) without/with Phase Plate

without phase plate



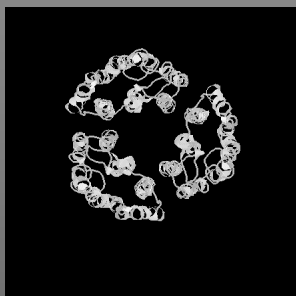
200 keV
 $C_s=2.7$ mm
focus



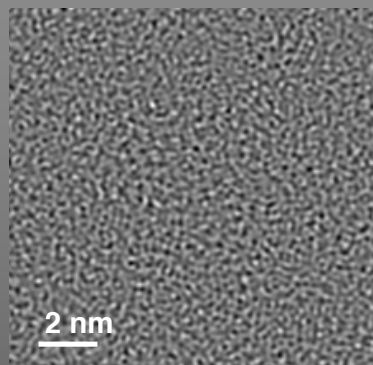
Simulation of bacterio rhodopson (bR) without/with Phase Plate

without phase plate

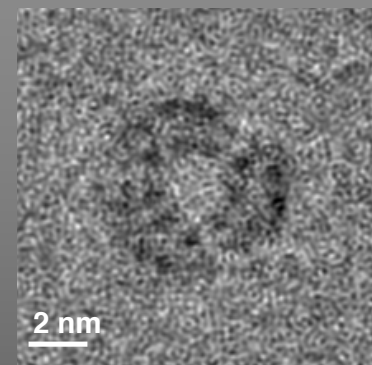
with phase plate



200 keV
 $C_s=2.7$ mm
focus



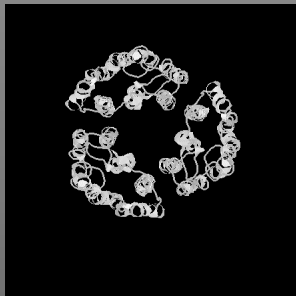
$\pi/2$ -phase shift
→
phase plate



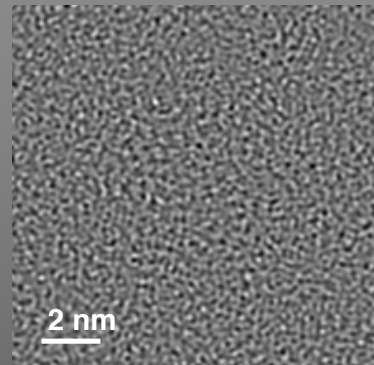
Simulation of bacterio rhodopsin (bR) without/with Phase Plate

without phase plate

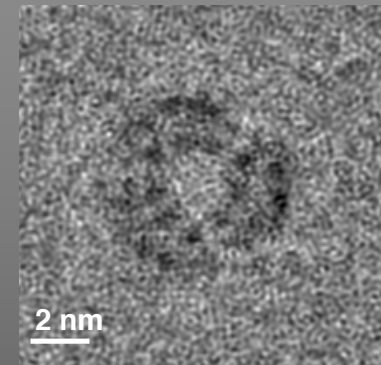
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200 keV
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$\pi/2$ -phase shift
 →
 phase plate

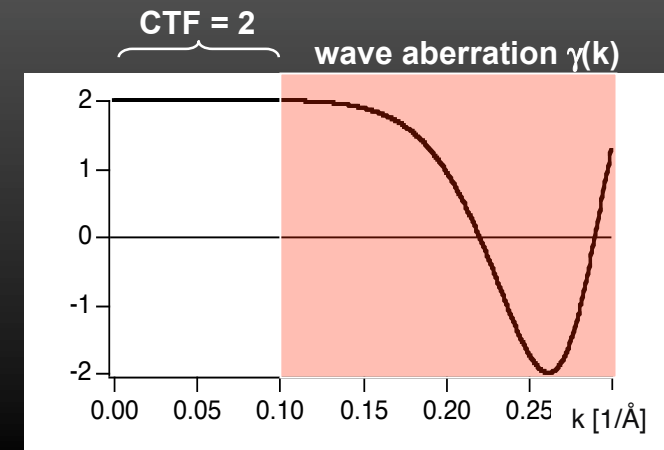
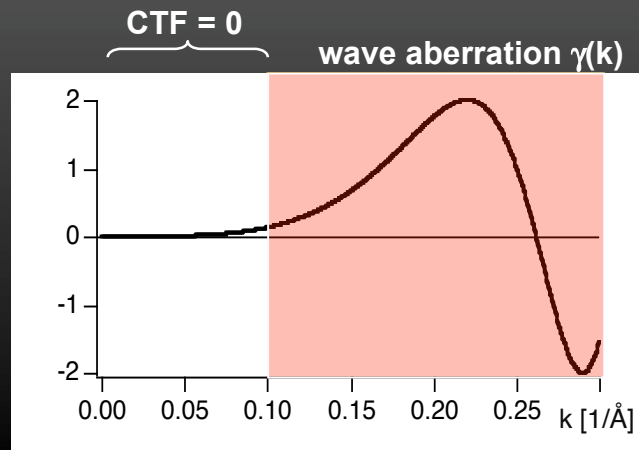


CTF(k) = Contrast Transfer Function (k = spatial frequency)

$$\text{CTF}(k) = 2 \sin \gamma(k)$$

$$\text{CTF}_{\pi/2}(k) = 2 \cos \gamma(k)$$

Fourier space

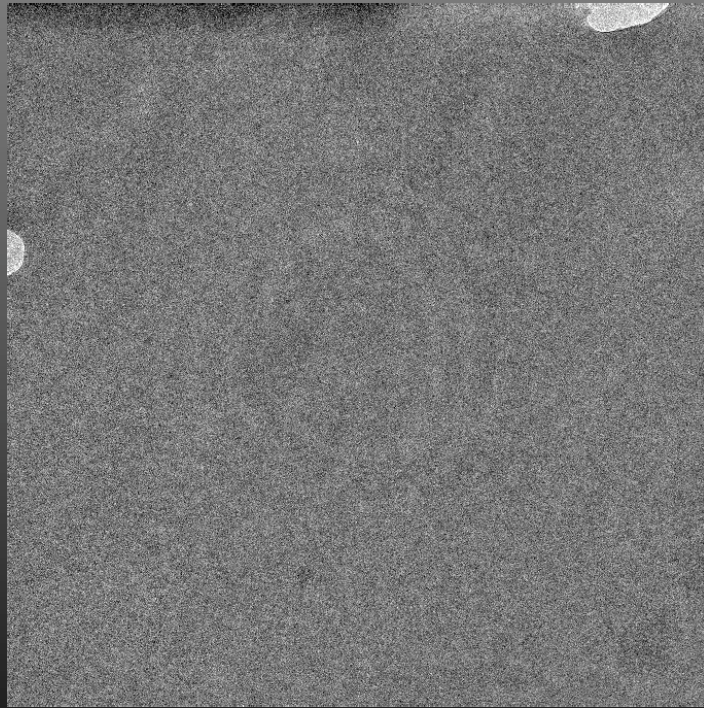


C. elegans Cell Section

High pressure frozen, freeze substituted without stain (Martin Müller)

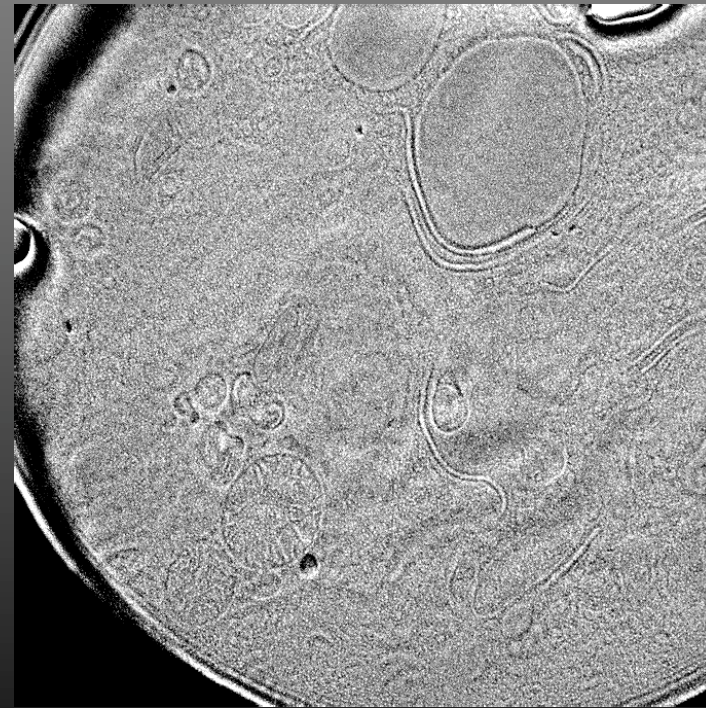
Images taken at 300keV, JEOL 3100 EFE at 4K specimen temperature (Kuniaki Nagayama)

conventional bright field



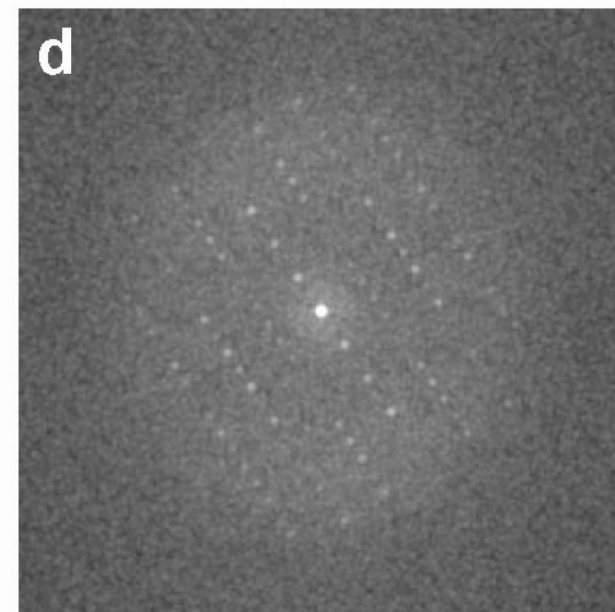
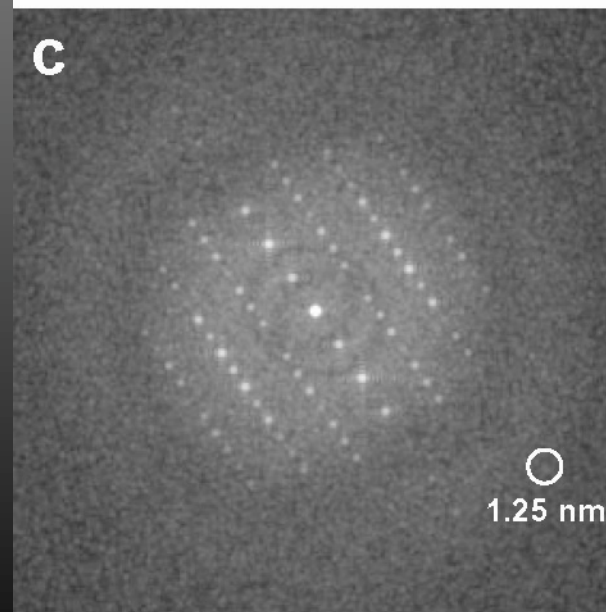
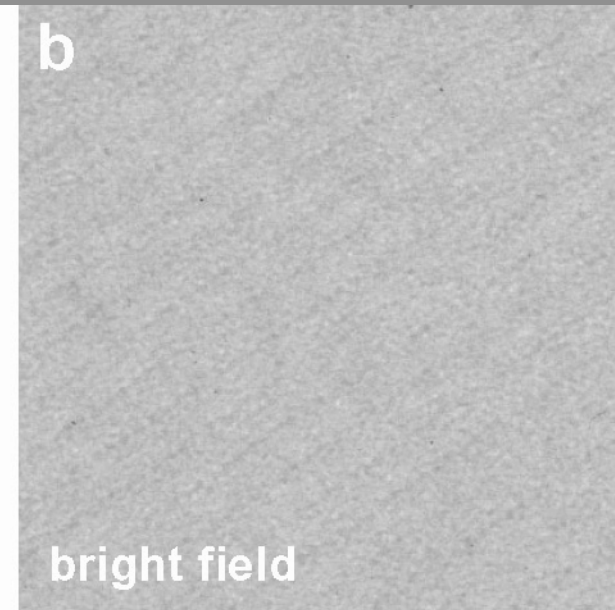
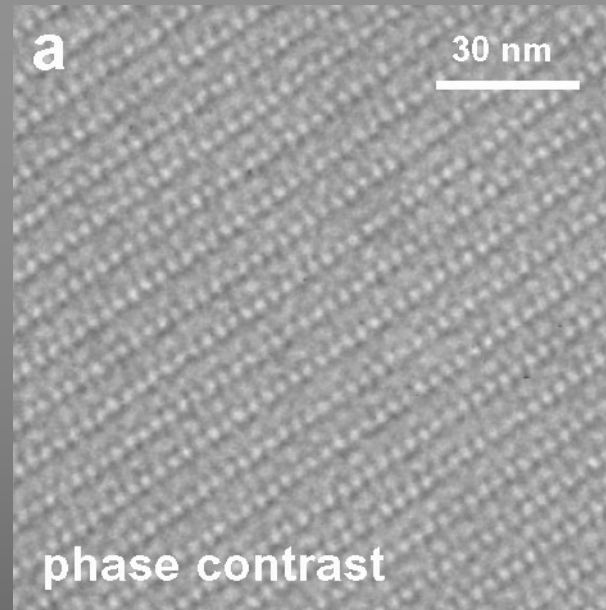
(field of view 50 μ m \times 50 μ m)

Zernike phase contrast (hole in C-film)



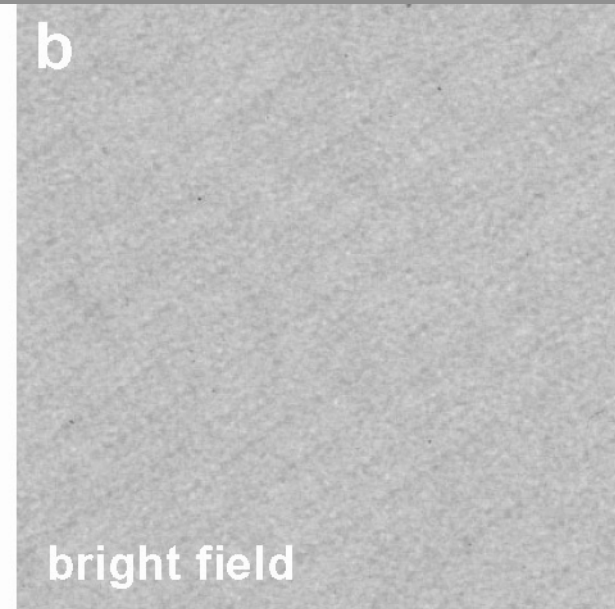
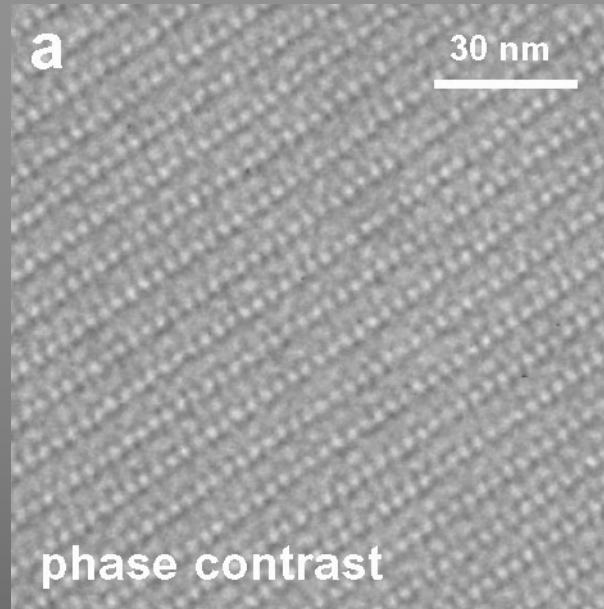
**Catalase
protein crystal
(ice embedding)**

Zeiss-NTS 922
FEG EFTEM

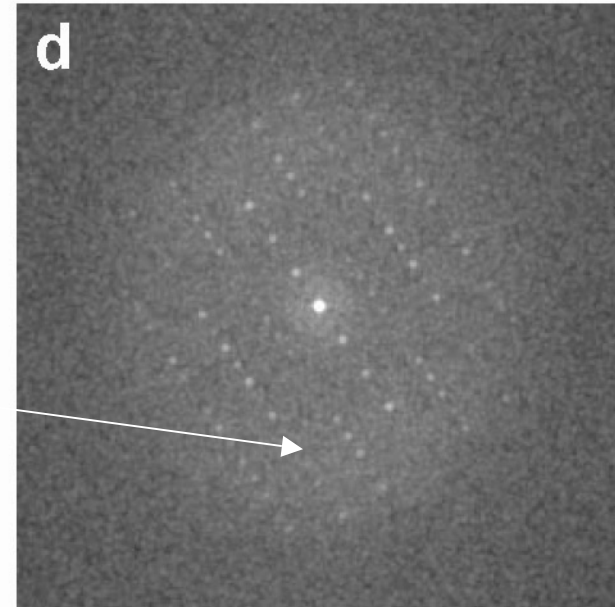
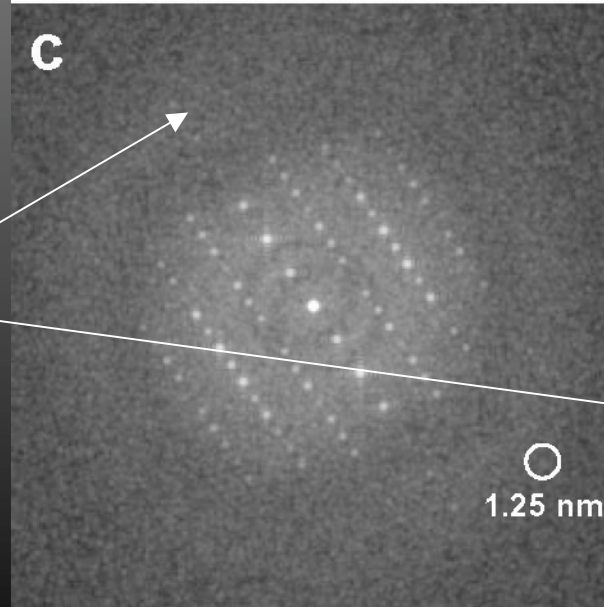


Catalase
protein crystal
(ice embedding)

Zeiss-NTS 922
FEG EFTEM



Thon rings =
show directly
the ICTFI²



Transfer function and wave aberration

without phase plate

$$CTF \sim -2 \sin\left(\frac{\pi}{2}(C_s \lambda^3 k^4 - 2\Delta_z \lambda k^2)\right)$$

with phase plate

$$CTF \sim -2 \sin\left(\frac{\pi}{2}(C_s \lambda^3 k^4 - 2\Delta_z \lambda k^2) + \varphi(k)\right)$$

+90° phase shift

$$CTF \sim -2 \cos\left(\frac{\pi}{2}(C_s \lambda^3 k^4 - 2\Delta_z \lambda k^2)\right)$$

C_s correction
(spherical aberration)

$$CTF \sim -2 \cos\left(\frac{\pi}{2}(0 - 2\Delta_z \lambda k^2)\right)$$

in focus

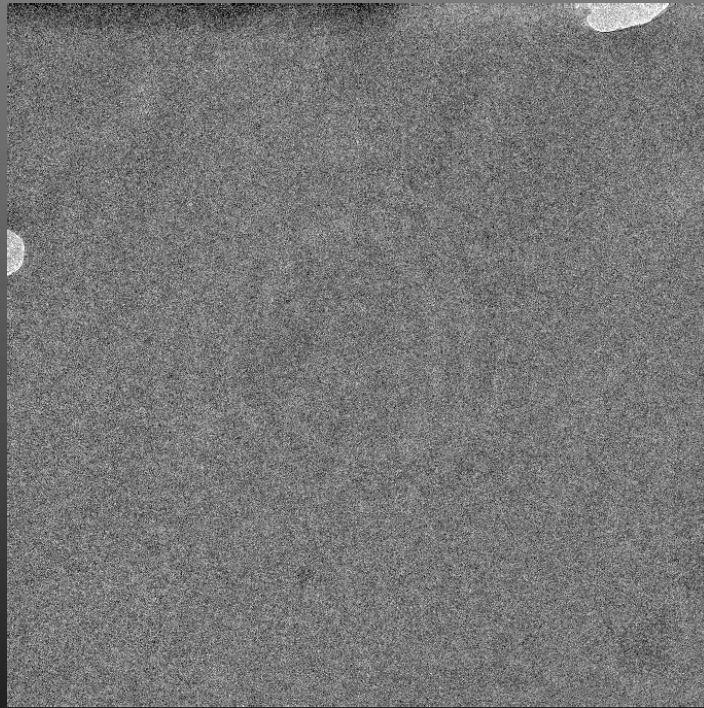
$$CTF \sim -2 \cos\left(\frac{\pi}{2}(0 - 0)\right) = 2 \cos 0 = 2$$

C. elegans Cell Section

High pressure frozen, freeze substituted without stain (Martin Müller)

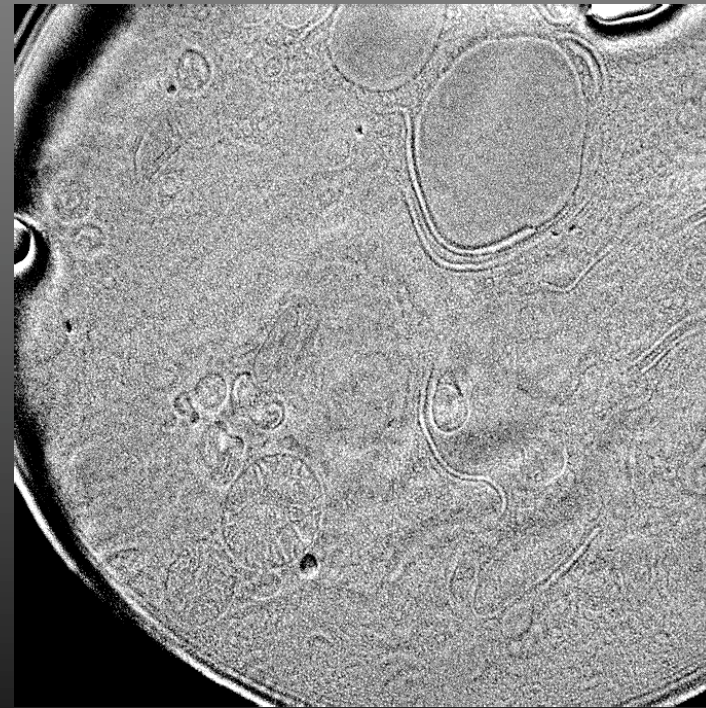
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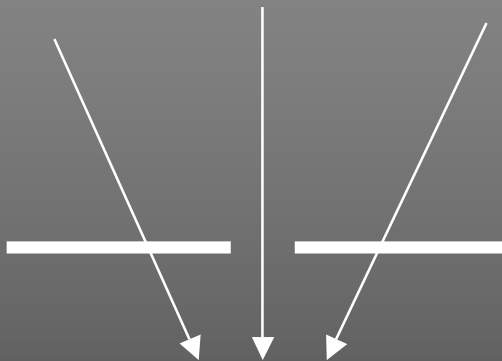
(field of view 50 μ m \times 50 μ m)

Zernike phase contrast (hole in C-film)



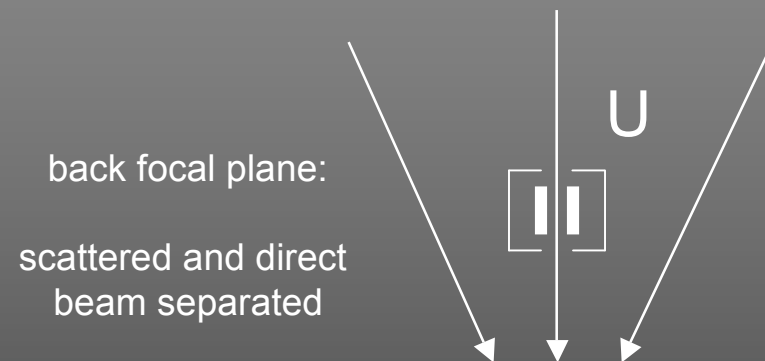
Two Types of Phase Plates

Zernike



- phase shift of scattered electrons by inner potential of carbon film
- loss of coherence
- granularity \Rightarrow non-constant phase shift
- contamination \Rightarrow charging

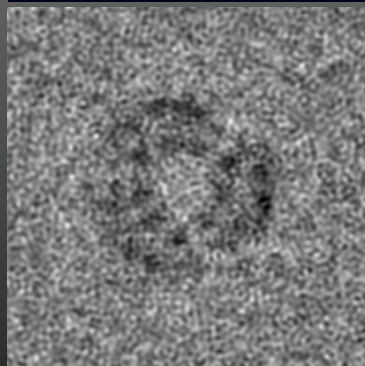
Boersch



- phase shift of central beam by electrostatic potential
- no interaction with matter
- adjustable potential / phase shift
- no contamination

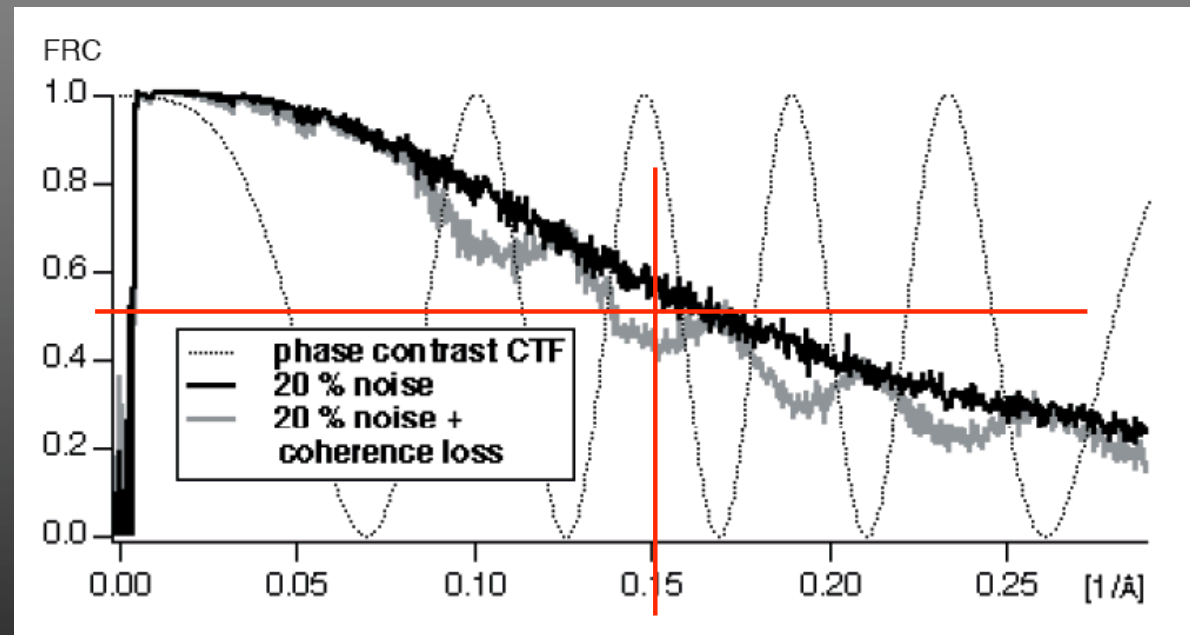
Measure resolution as a function of noise and coherence loss by Zernike-type thin film phase plate

original



simulated phase contrast image

Fourier ring correlation



resolution limit 6-8 Å
cmp: 2-3 Å by electron crystallography

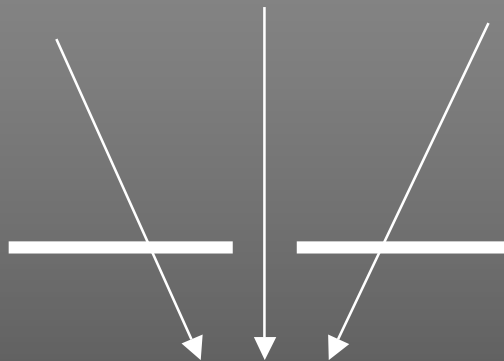
Majorovits and RRS, unpublished

Prerequisites for ideal phase plate

- phase shift by magnetic or electric field
 - > no additional scattering
- no other effects than homogeneous phase shift
 - > non-homogeneous effects (lens)
 - > obstructions in the back focal plane

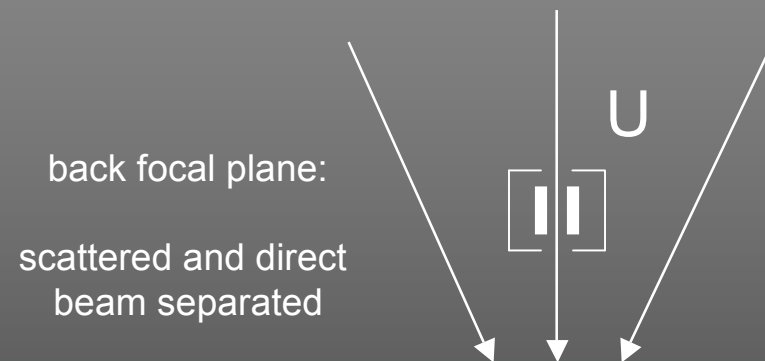
Two Types of Phase Plates

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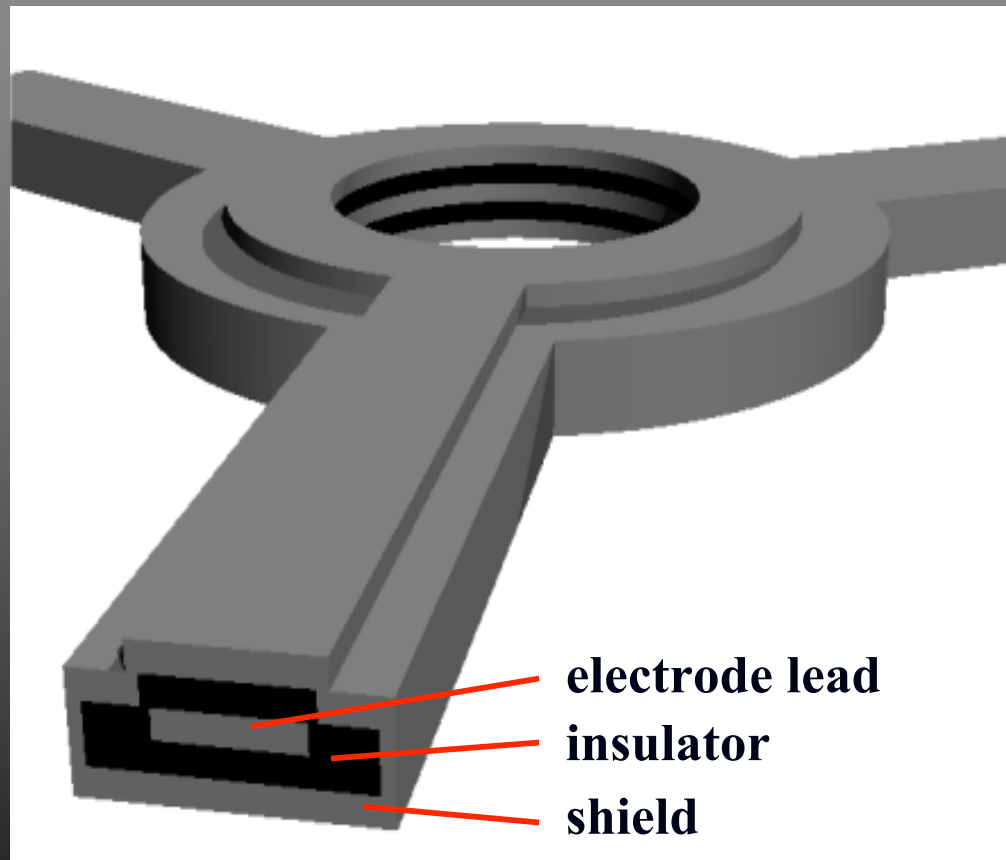
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Boersch



- phase shift of central beam by electrostatic potential
- no interaction with matter
- adjustable potential / phase shift
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Design of the Boersch Phase Plate



- Realization of an electrostatic microlens by a five-layered electrode structure in the center of the phase plate
- Confinement of the electrical field to the central lens opening by surrounding Au layer

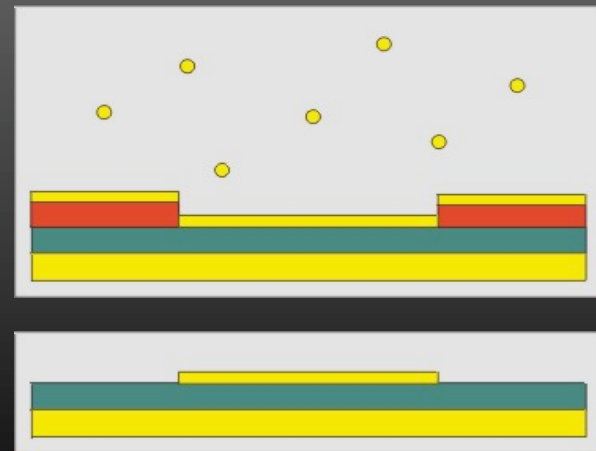
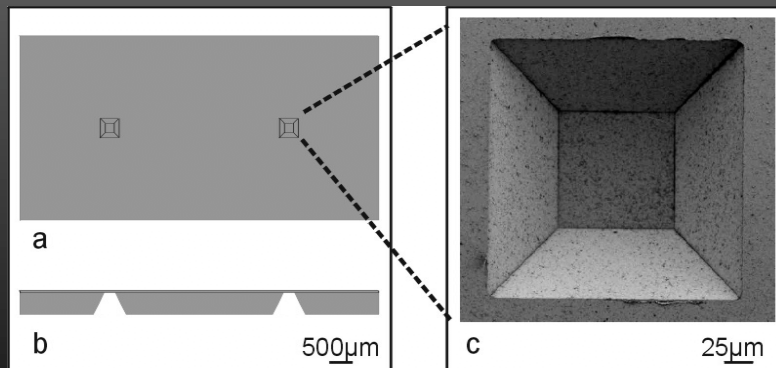
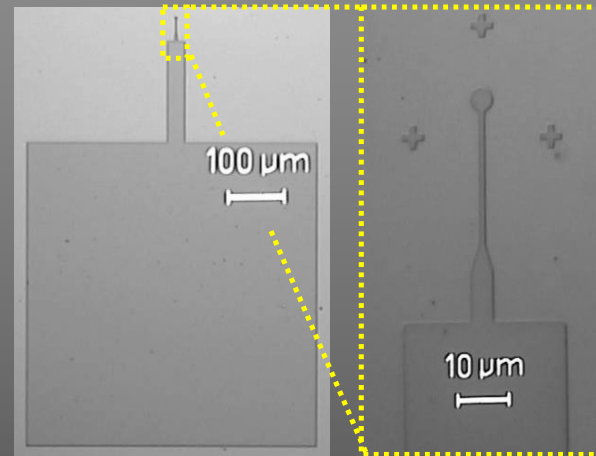
Matsumoto and Tonomura, Ultramicroscopy, 63 (1996)

Schultheiß et al., J. Instrum. Res. 77 (2006)

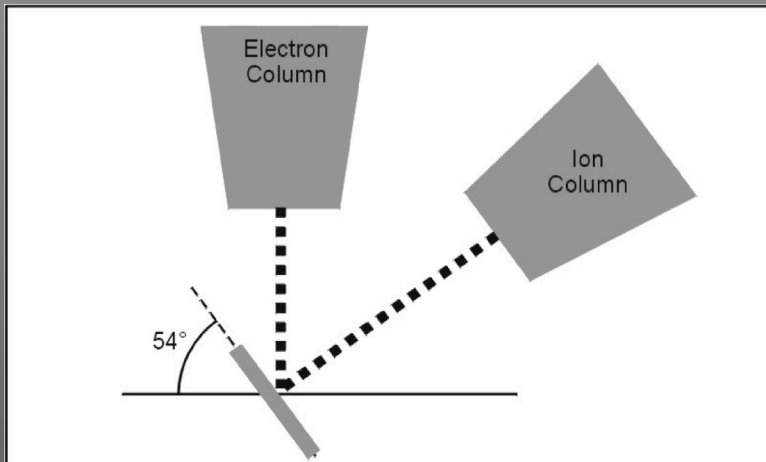


Substrate Material / Lower 3 Layers

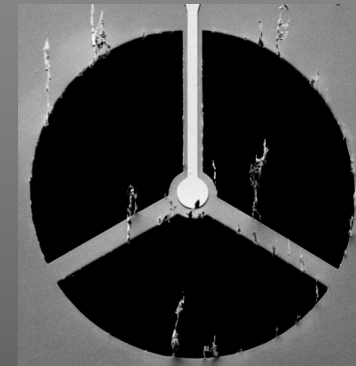
- Commercially available low-stress $\text{Si}_{3+x}\text{N}_{4-x}$ membranes as basic material
- Electron-beam evaporation of the lower shielding Au layer
- Patterning of the electrode layer by electron-beam lithography



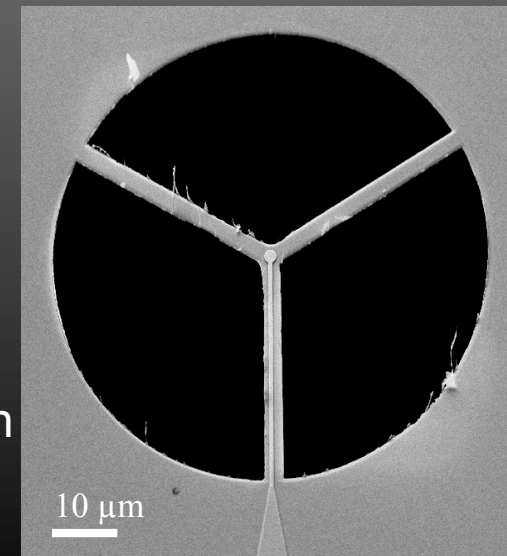
Focused Ion Beam (FIB) Lithography



- Shaping of phase plate by FIB lithography



First tested design

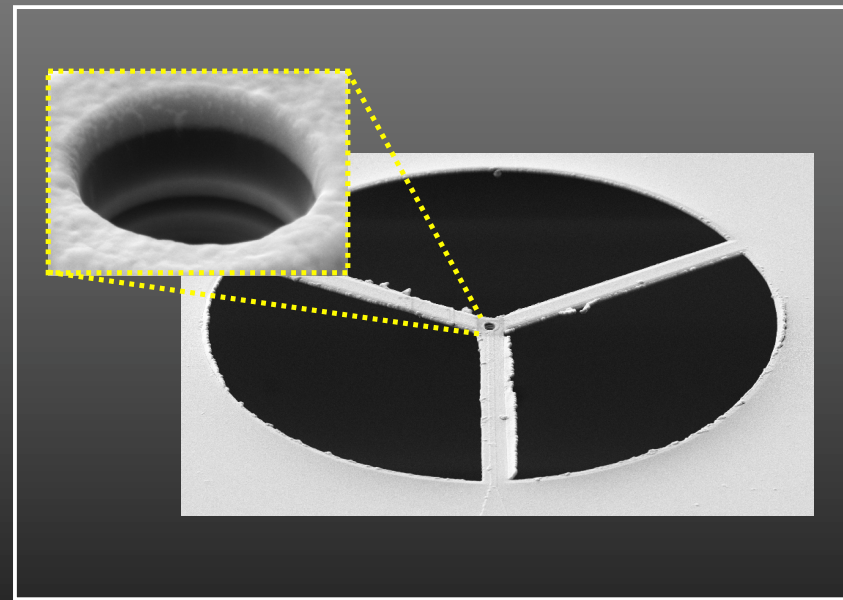
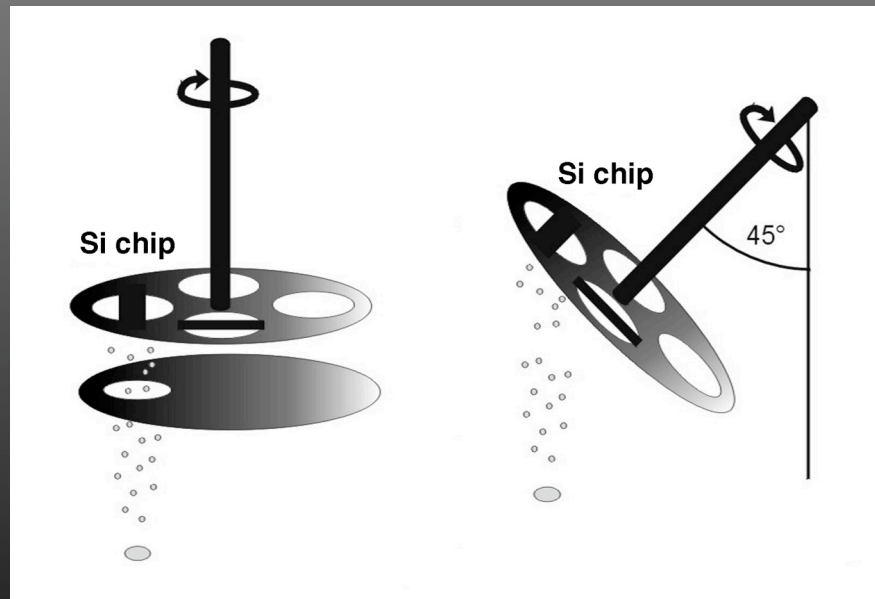


Improved design with reduced supporting bar width



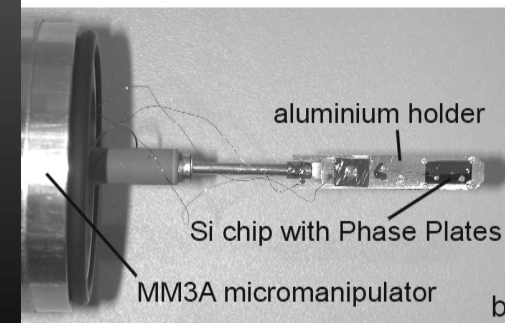
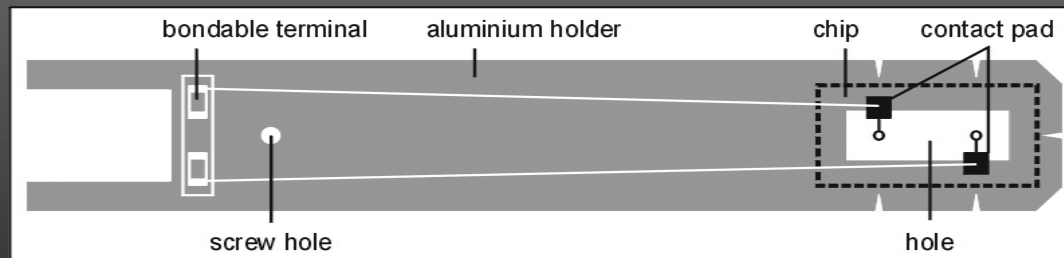
Shielding Layer / Central Hole

- Electron-beam evaporation of 2nd insulating layer (Al_2O_3)
- Electron-beam evaporation of shielding gold layer in tilted rotating holder
- Central lens opening by FIB milling



Connection and Implementation

- Chip glued on an aluminium holder
- Mounting of aluminium holder on a piezodriven micro manipulator to position the phase plate in the back focal plane
- Electrical bushing through flange



Transfer function and wave aberration

without phase plate

$$CTF \sim -2 \sin\left(\frac{\pi}{2}(C_s \lambda^3 k^4 - 2\Delta_z \lambda k^2)\right)$$

with phase plate

$$CTF \sim -2 \sin\left(\frac{\pi}{2}(C_s \lambda^3 k^4 - 2\Delta_z \lambda k^2) + \varphi(k)\right)$$

+90° phase shift

$$CTF \sim -2 \cos\left(\frac{\pi}{2}(C_s \lambda^3 k^4 - 2\Delta_z \lambda k^2)\right)$$

C_s correction
(spherical aberration)

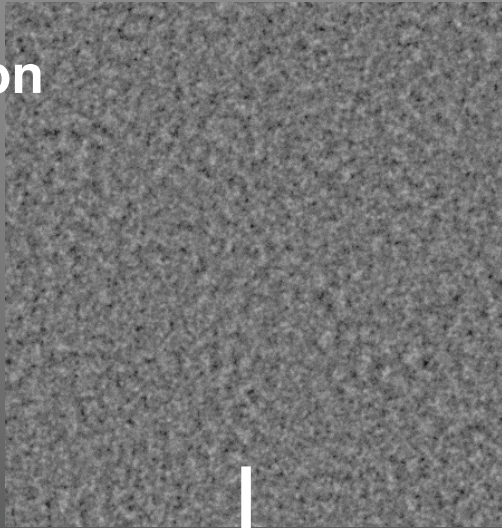
$$CTF \sim -2 \cos\left(\frac{\pi}{2}(0 - 2\Delta_z \lambda k^2)\right)$$

in focus

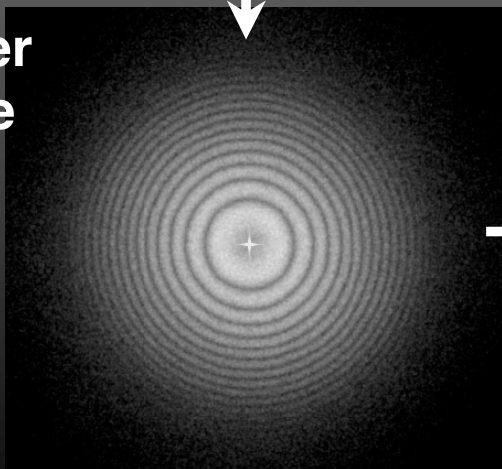
$$CTF \sim -2 \cos\left(\frac{\pi}{2}(0 - 0)\right) = 2 \cos 0 = 2$$

Quantitation of phase shift using carbon film

carbon
film

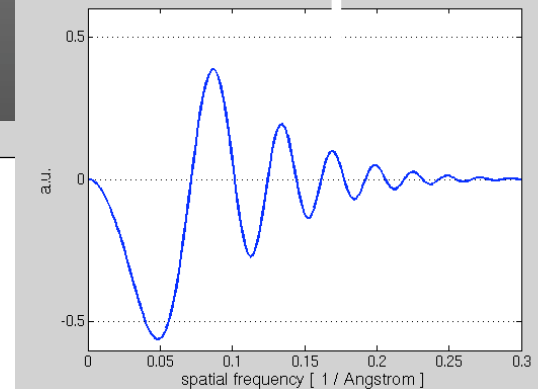
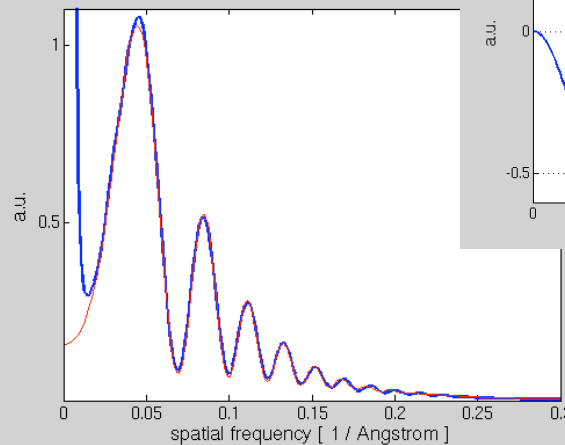


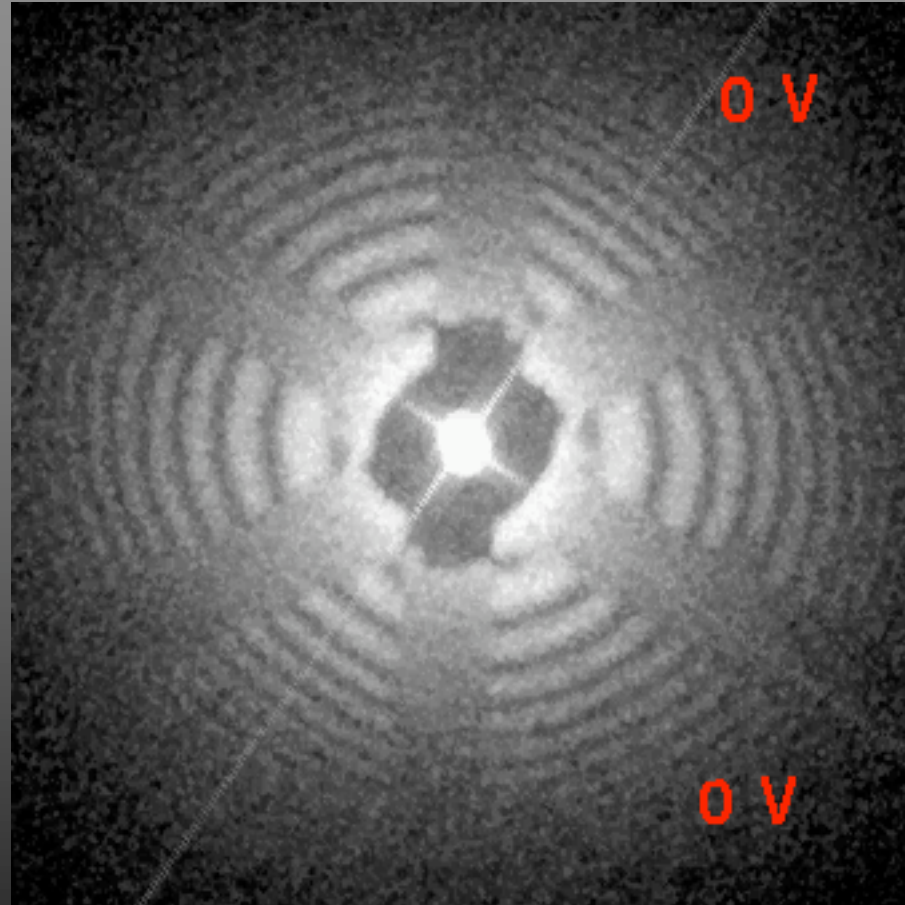
Fourier
space

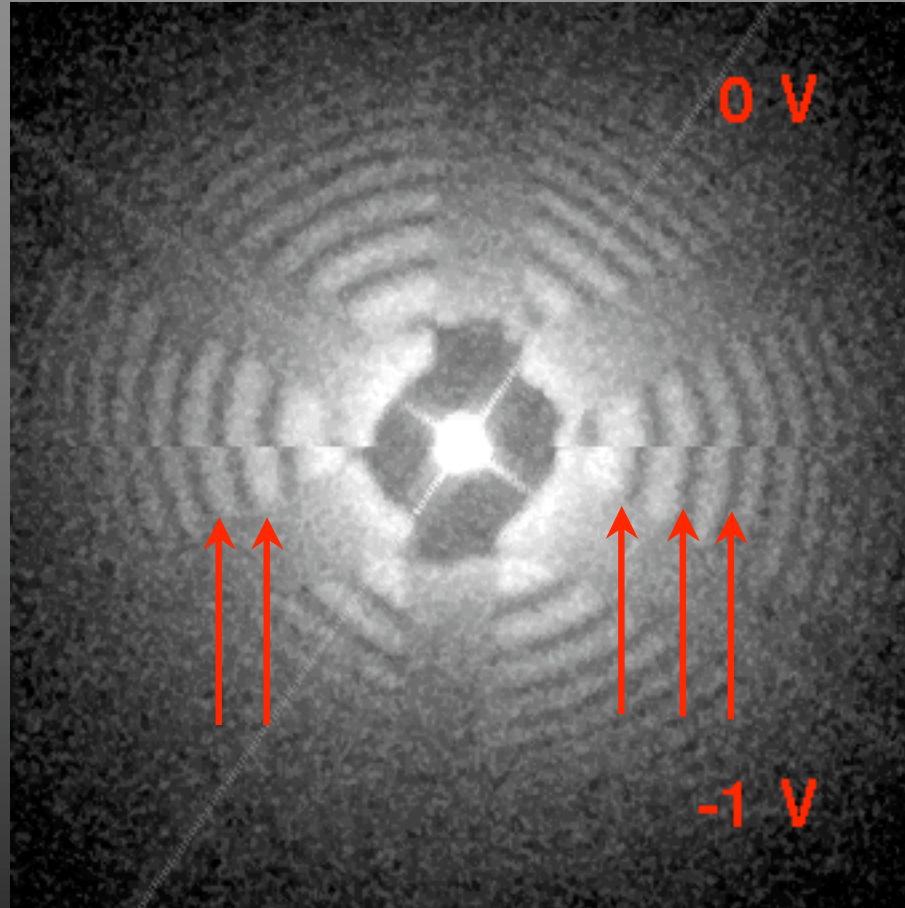


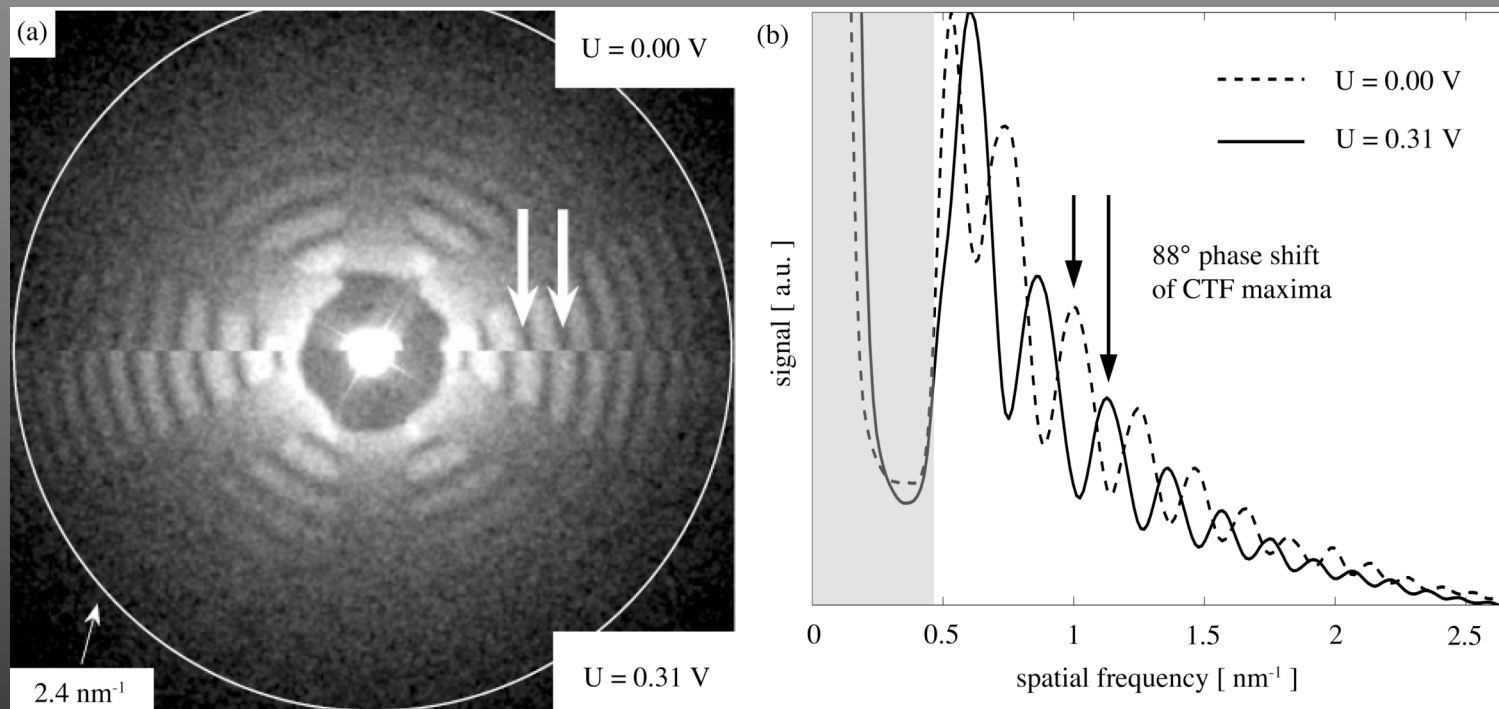
$$CTF \sim -2 \sin \left(\frac{\pi}{2} (C_s \lambda^3 k^4 - 2\Delta z \lambda k^2) + \varphi(k) \right)$$

$\varphi(k) = \textit{phase shift}$



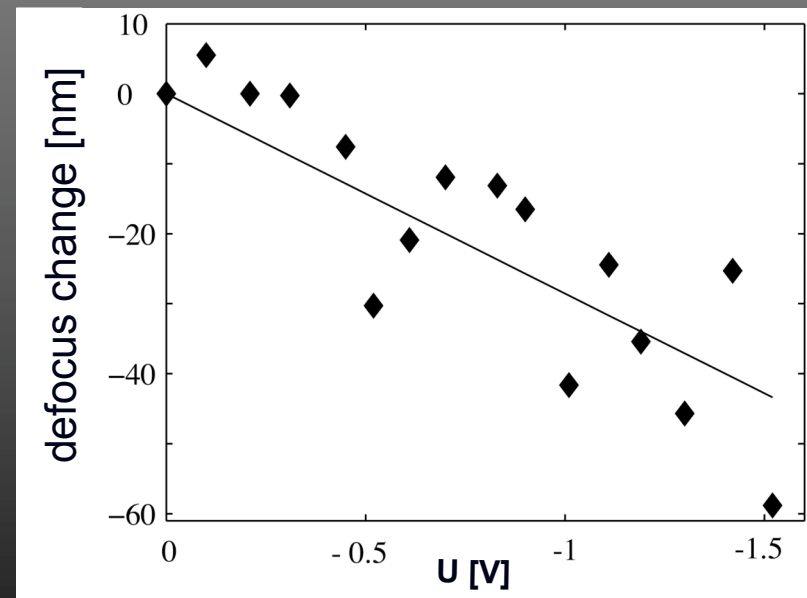
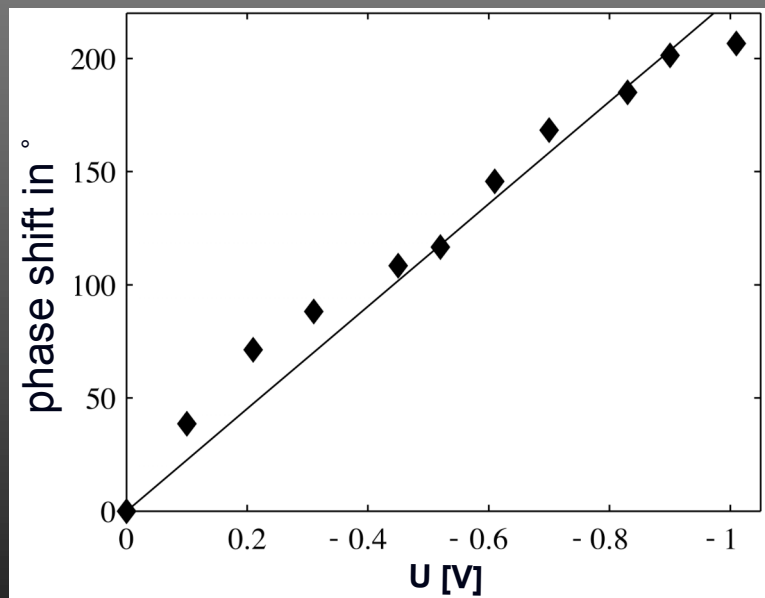




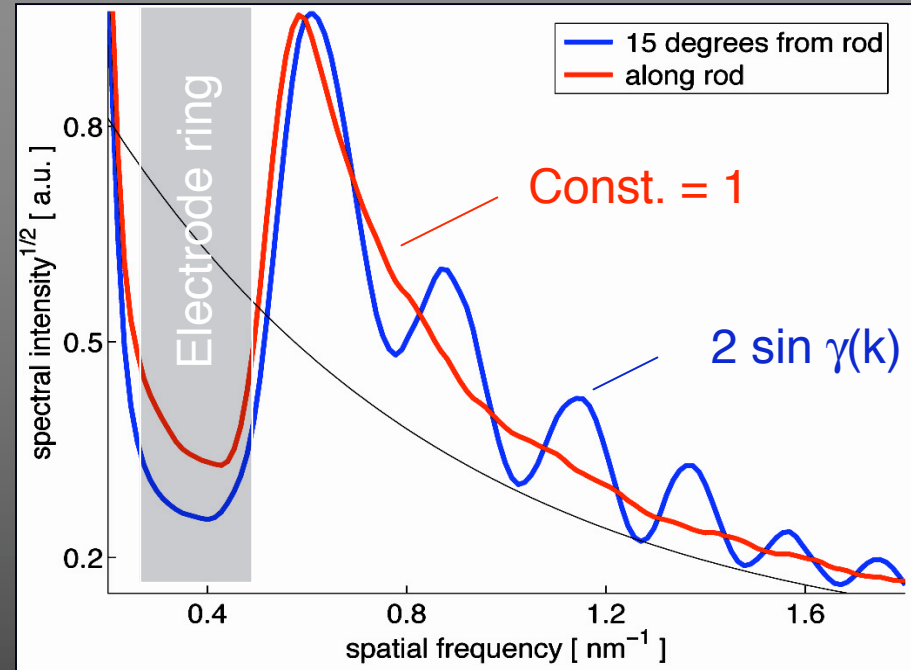
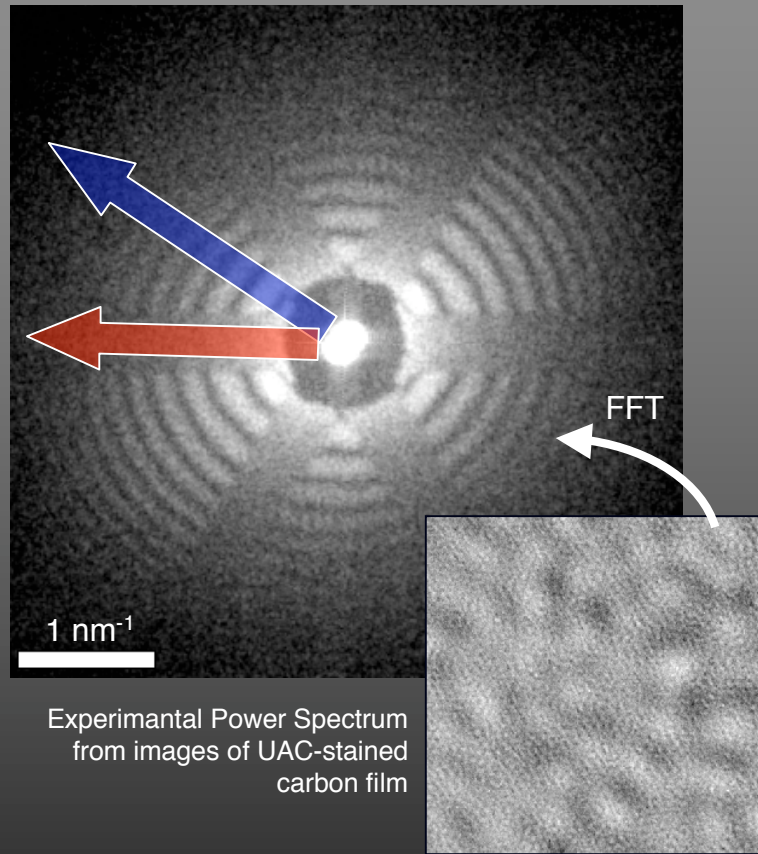


It works!

- realisation of an electrostatic Boersch phase plate
- proof of principle of high resolution PCEM

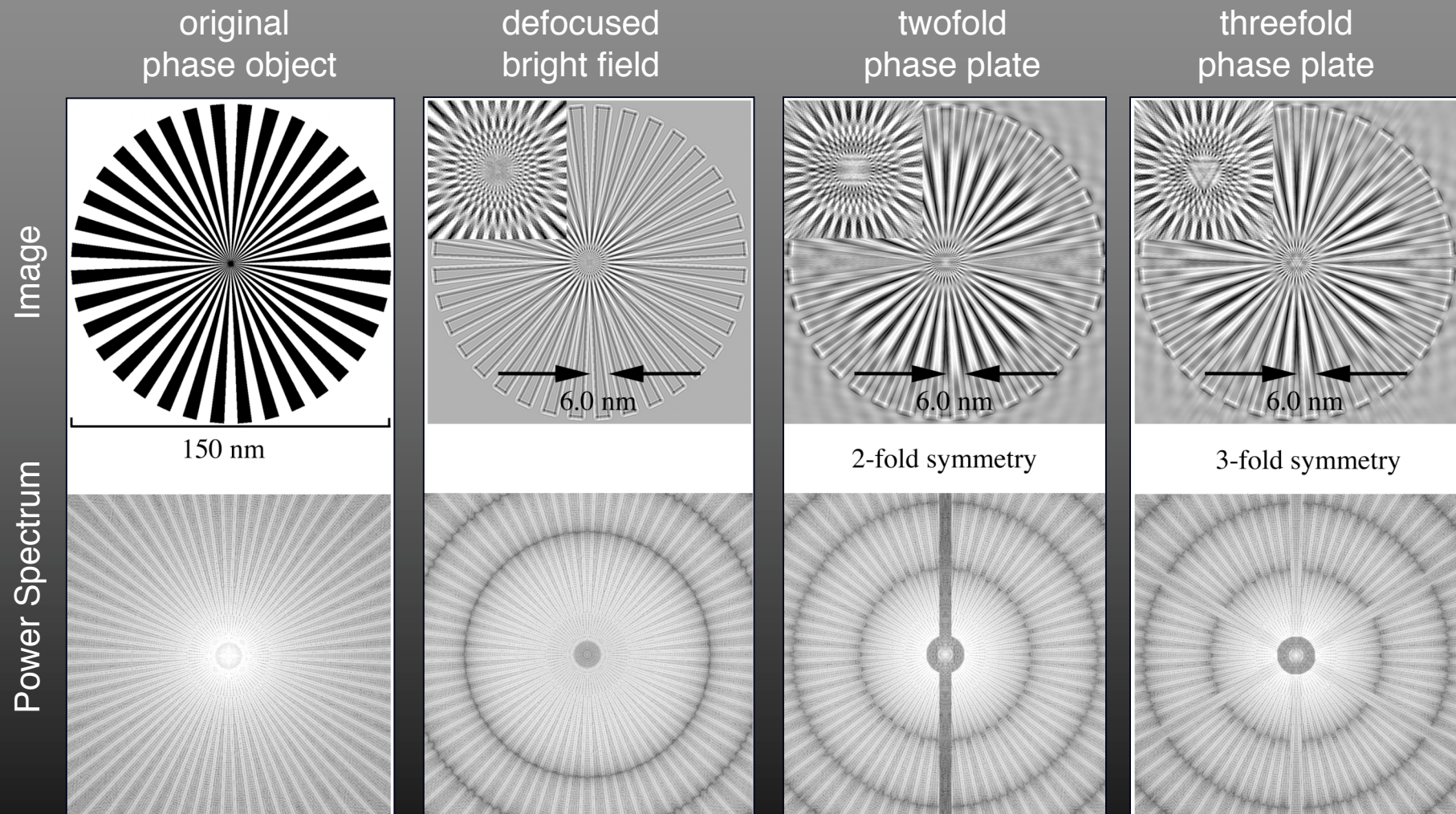


Measurement of Signal Transfer „Along“ Support Rod



➔ Non-oscillating single-sideband signal transfer by non-centrosymmetric support rods

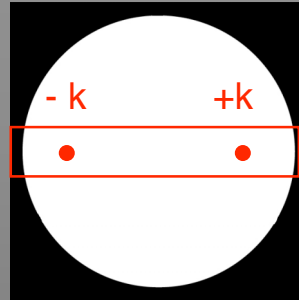
Threefold Support Symmetry Preserves Object Information and Reduces Imaging Artifacts



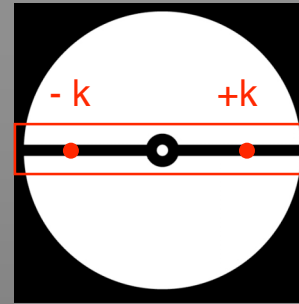
Simulation: Imaging of a weak phase object (Siemens star) with 120 kV TEM

Support geometry

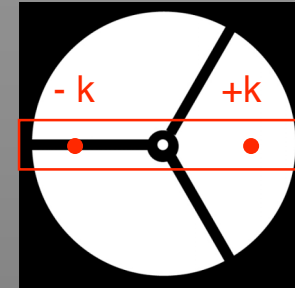
no phase plate



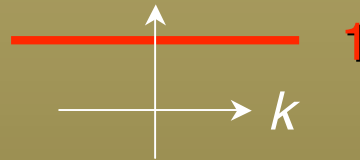
twofold PP



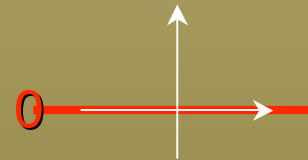
threefold PP



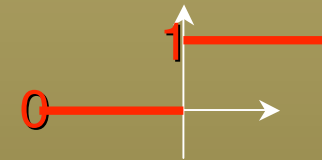
Phase Plate aperture function $A(k)$ in back focal plane (in rod direction)



One
 $A_0(k) = 1$



Zero
 $A_2(k) = 0$



Heaviside step function
 $A_3(k) = 1/2 \{ 1 + \text{sign}(k) \}$

Wave amplitude in BFP

$\delta(k) + i \varphi(k) \cdot e^{-iW(k)}$

$\delta(k)$

$\delta(k) + i/2 \varphi(k) \cdot e^{-iW(k)} \{ 1 + \text{sign}(k) \}$

Image frequency spectrum (Fourier transform)

$\delta(k) + \varphi(k) \cdot 2 \sin W(k)$

$\delta(k)$

$\delta(k) + \varphi(k) \cdot \underbrace{i \text{sign}(k) e^{-i \text{sign}(k) W(k)}}_{\text{PCTF = phase factor !}}$

Phase contrast transfer | PCTF (k) |

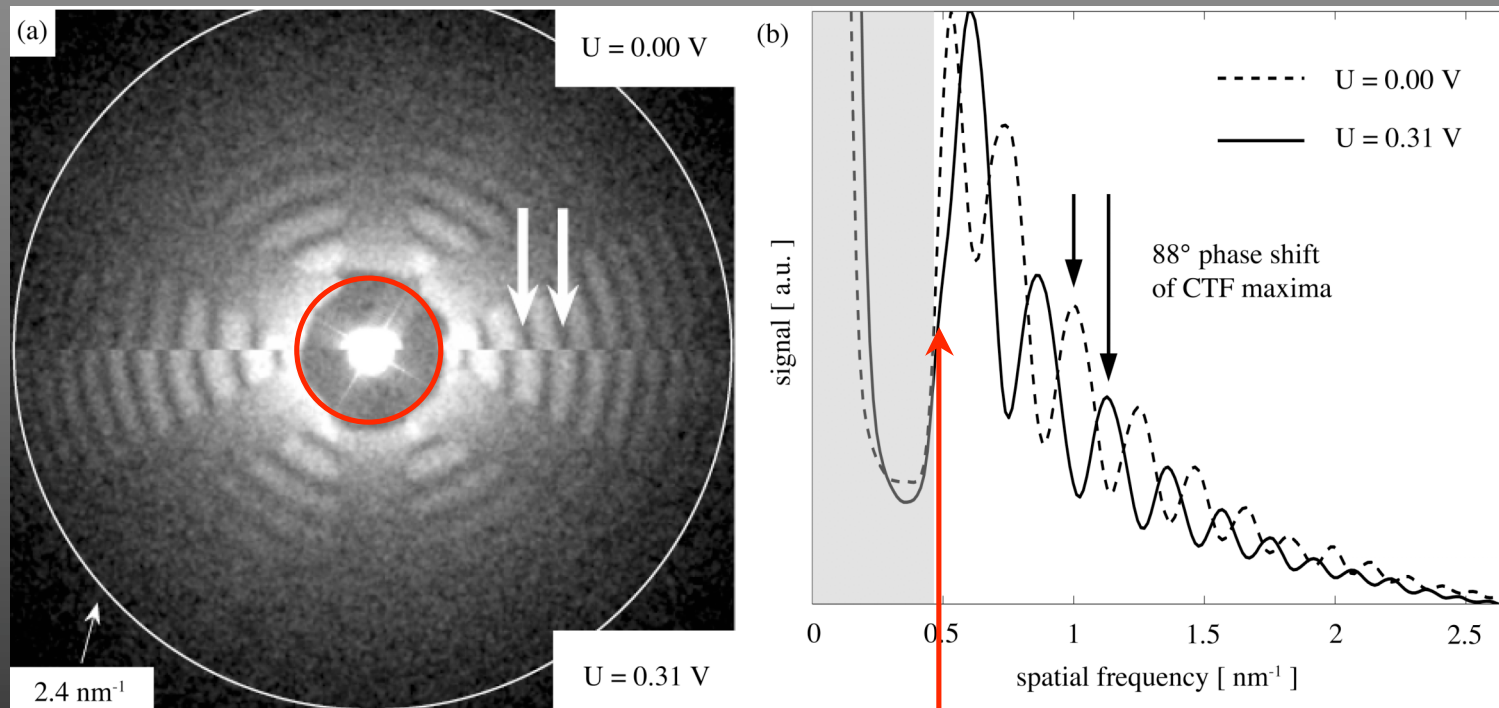
$2 |\sin W(k)|$

0

1

Another Problem:

Loss of Low Resolution Structure Factors

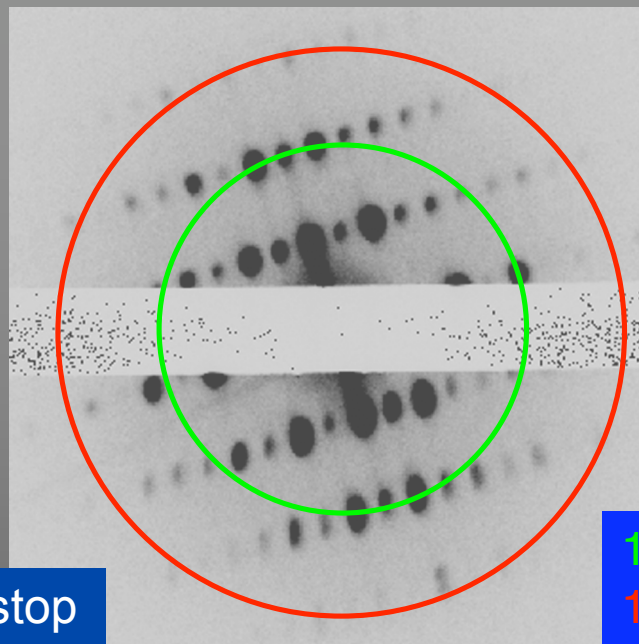


2 nm resolution ring

2 nm resolution cut-off

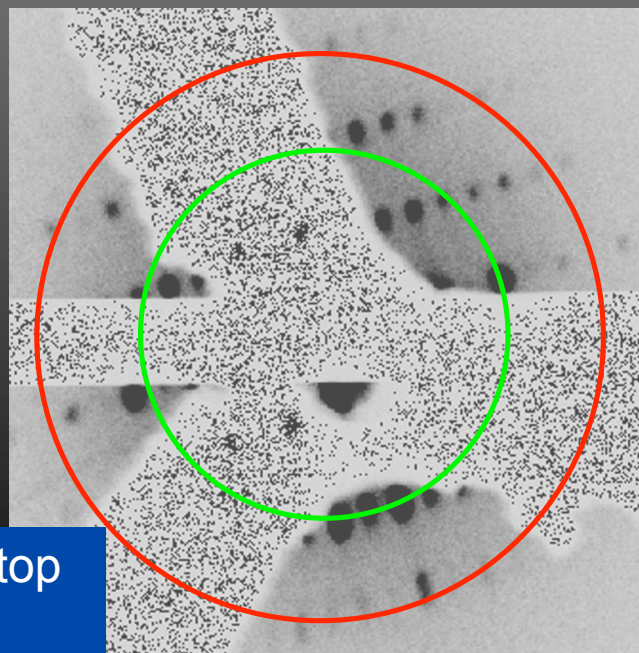
Electron diffraction patterns

(catalase micro crystals, negative stain
100keV, 3mm focal length)



Shadow of beam stop

1/3.5nm
1/2.3nm

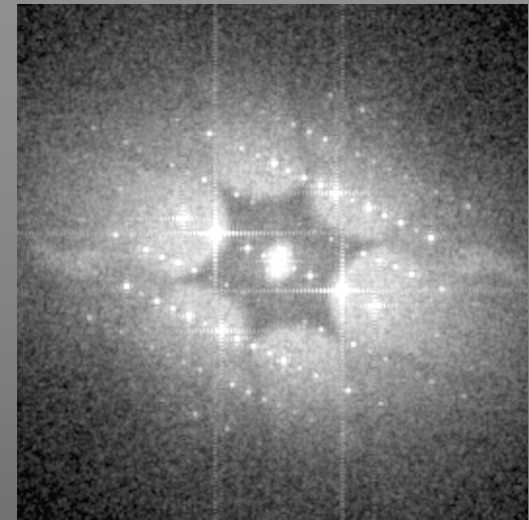


Shadow of beam stop
and phase plate

Imaging

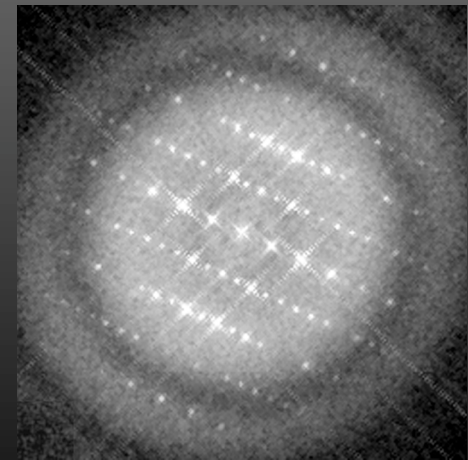
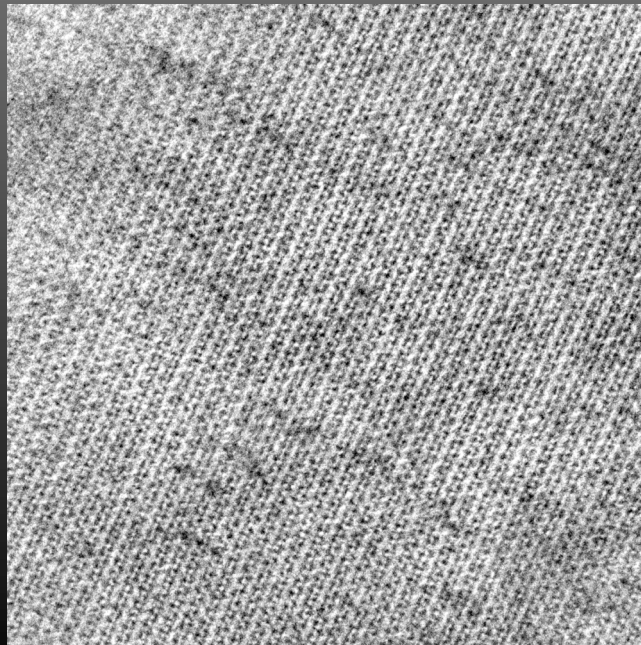
(catalase, negative stain, 100keV, 65kx on CCD 6.9nm, 17.3nm)

with phase plate in diff. plane



power spectra

conventional bright field



The Roadmap to High Resolution Phase Contrast EM

Proof of principle (structure factors 2nm - 4Å)



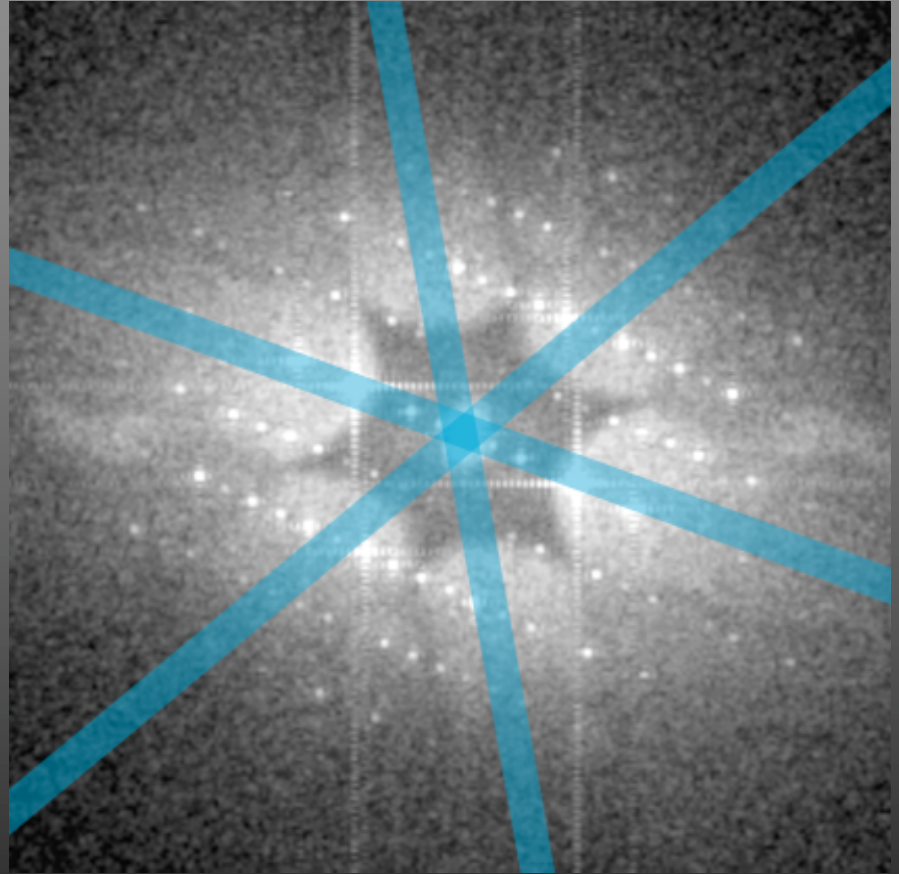
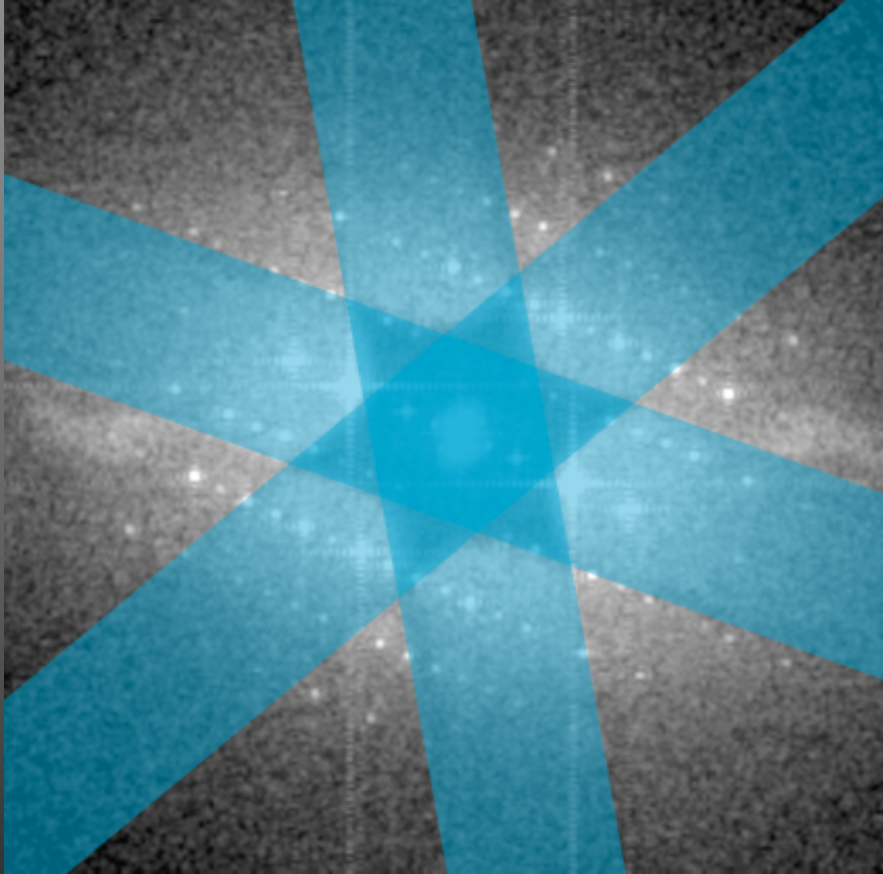
Smaller lens diameter (structure factors 4nm - 2Å) and thinner support rods



Increase effective size of diffraction pattern
(structure factors 40nm - 2Å)



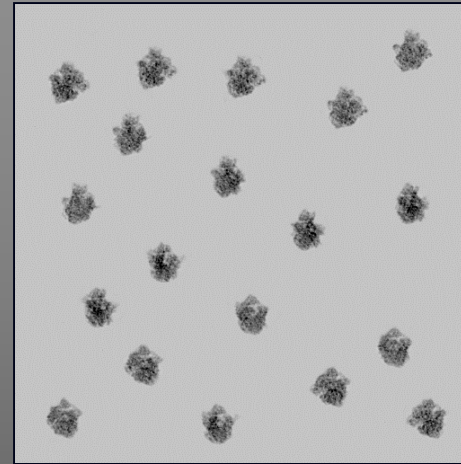
Artefact-free imaging of objects of typical size of 20-30nm



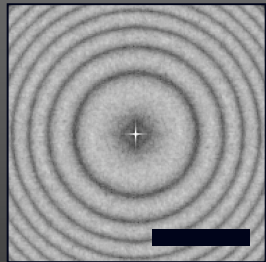
Reducing Signal Obstruction by the Phase Plate

Simulate the optical magnification of back focal plane (300kV, focal length 2.2mm)

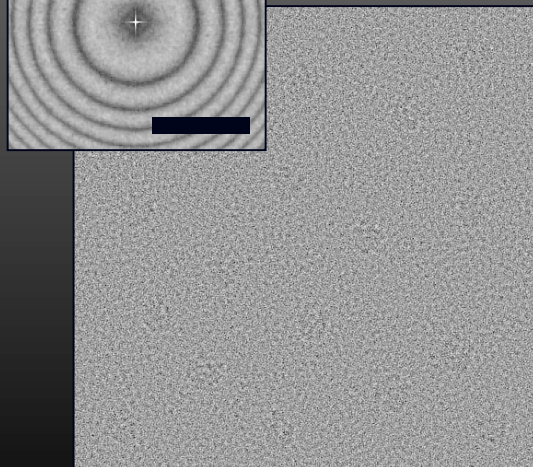
Test object: field of different ribosome projections (from PDB) with simulated ice embedding



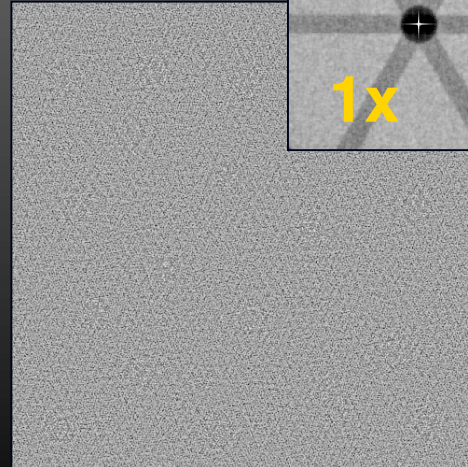
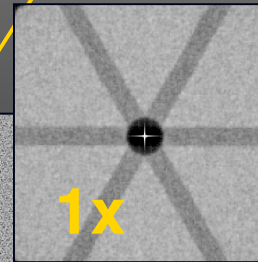
Bright Field
1 μm underfocus



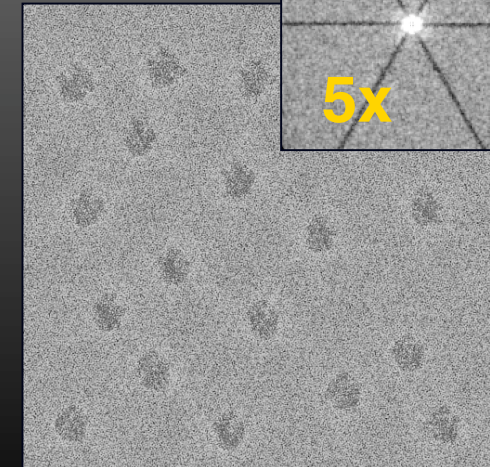
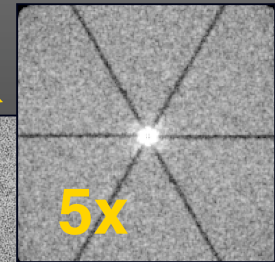
SNR = 0.61



SNR = 0.68



SNR = 1.64



3-fold Boersch Phase Plate, in gaussian focus

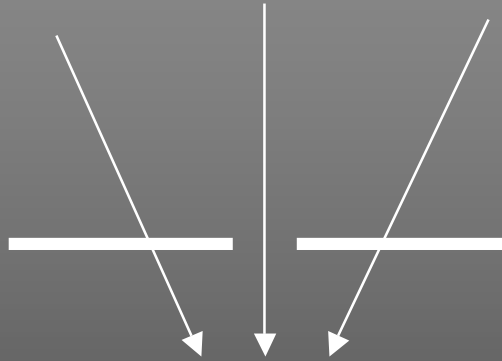
Conclusion and future work

- phase shift by electric field shown (proof of principle)
 - > no additional scattering
 - no other effects than homogeneous phase shift
 - > non-homogeneous effects (lens)
 - > obstructions in the back focal plane
- > Design and construct a lens doublet to magnify the back focal plane (problems with spherical aberration, resolution ...)

Majorovits et al., Ultramicroscopy, in press (2006 or 2007)
on the web under: doi 10.1016/j.ultramic.2006.7.006

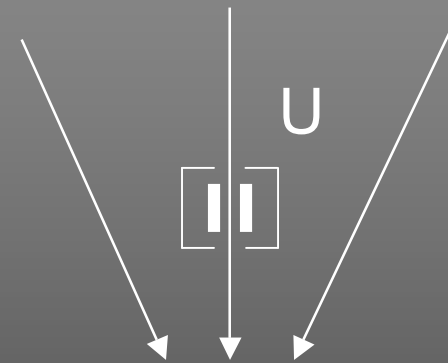
Two Types of Phase Plates

Thin-film Zernike



Fritz Zernike

Boersch



Hans Boersch